

# Modern PV-Technologies

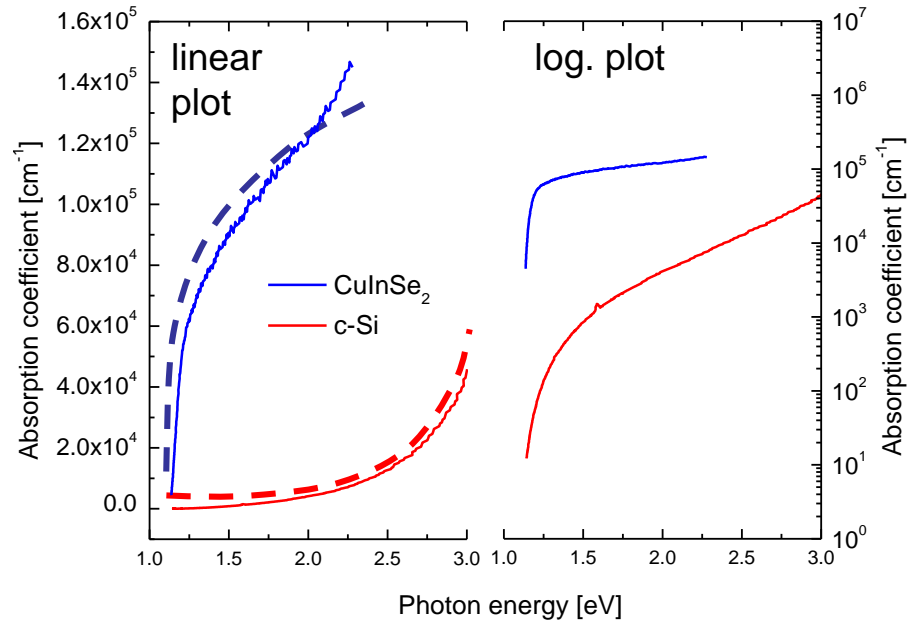
## 3.4: Optics

F.-J. Haug

Ecole Polytechnique Fédérale de Lausanne  
PV-Lab

# Absorption coefficient

## Direct vs. indirect band gap



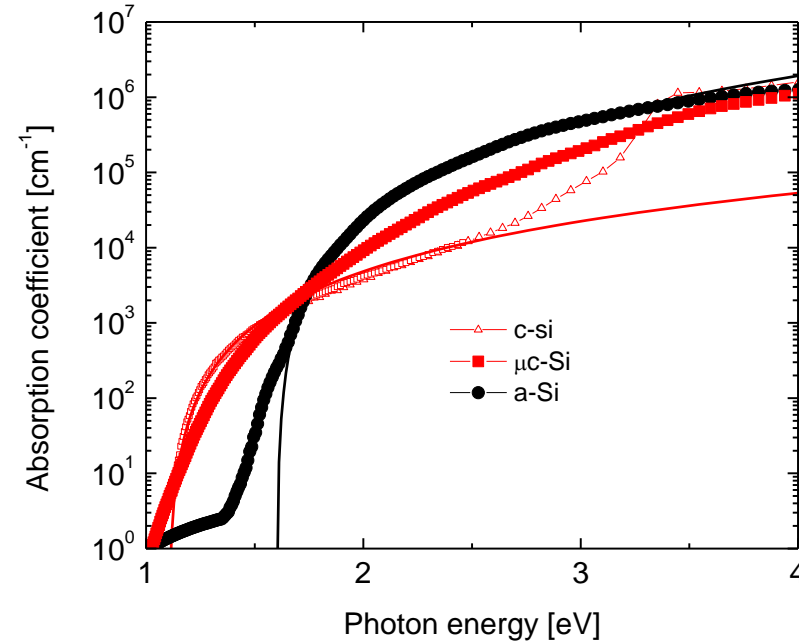
Direct gap (GaAs,  $\text{CuInSe}_2$ ):

$$\alpha \sim (E - E_g)^{1/2}$$

Indirect gap (c-Si):

$$\alpha \sim (E - E_g)^2$$

## Indirect gaps in all types of silicon



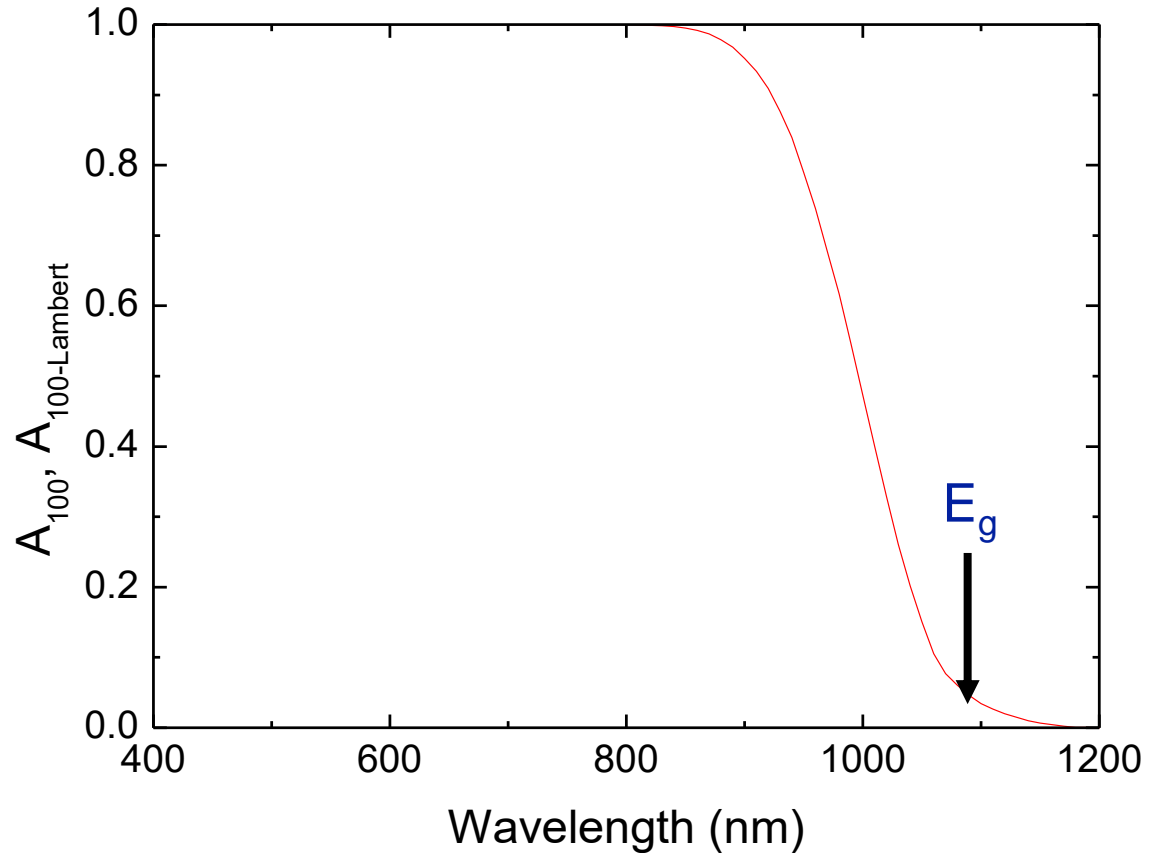
a-Si:H:  $\sim 1.75$  eV

$\mu\text{c-Si:H}$ :  $\sim 1.1$  eV (like c-Si)

weak IR absorption ( $< 10^4$   $\text{cm}^{-1}$ )

Green, Sol. En. Mat. 2008

# Absorption in silicon

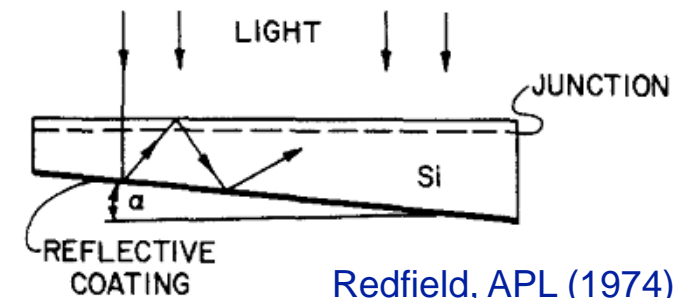


Workaround: path enhancement by texture

100  $\mu\text{m}$  thick wafer  
(may become standard)

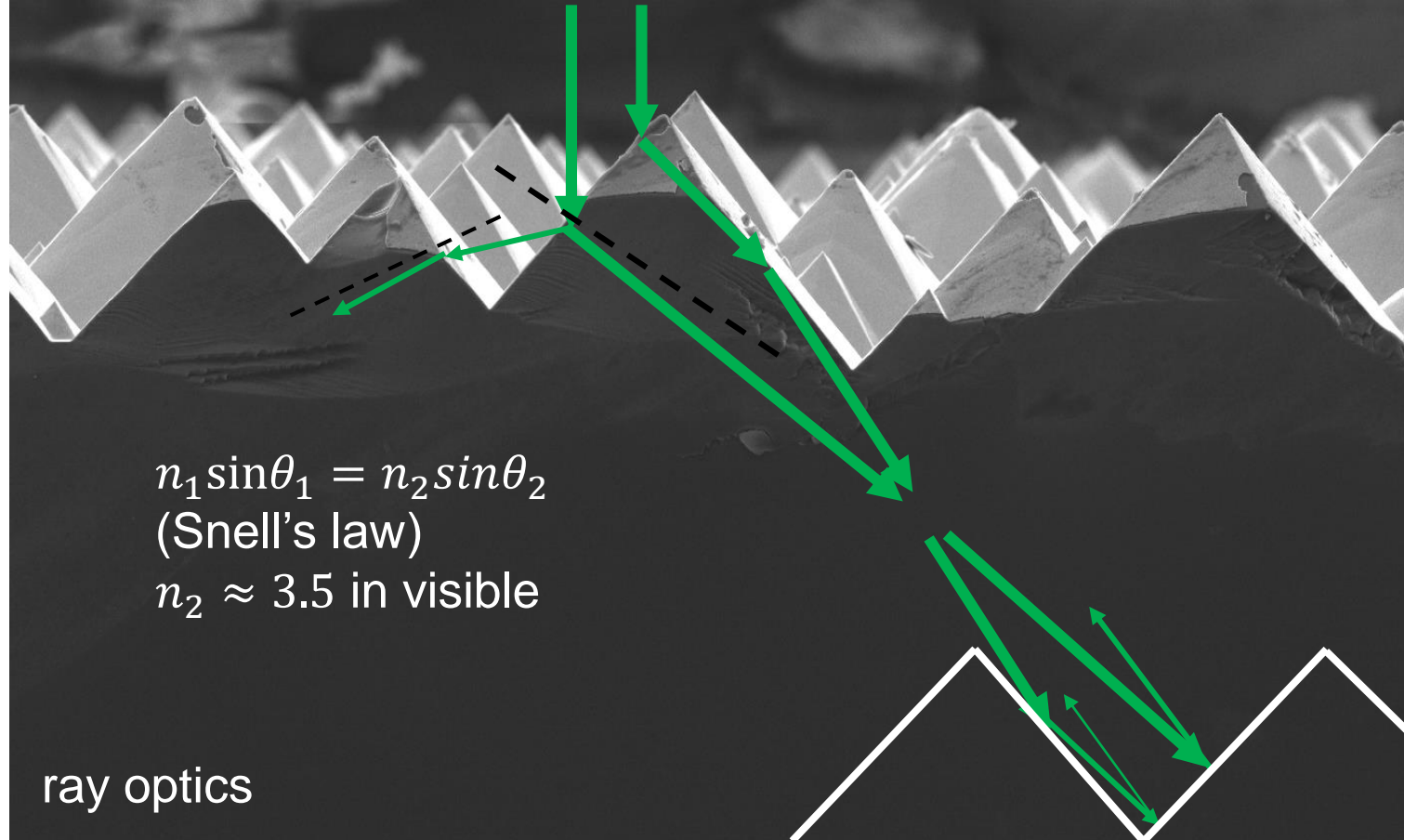
$$A = 1 - \exp\{-\alpha d\}$$

assumes ideal front  
anti-reflection,  
ideal back reflector



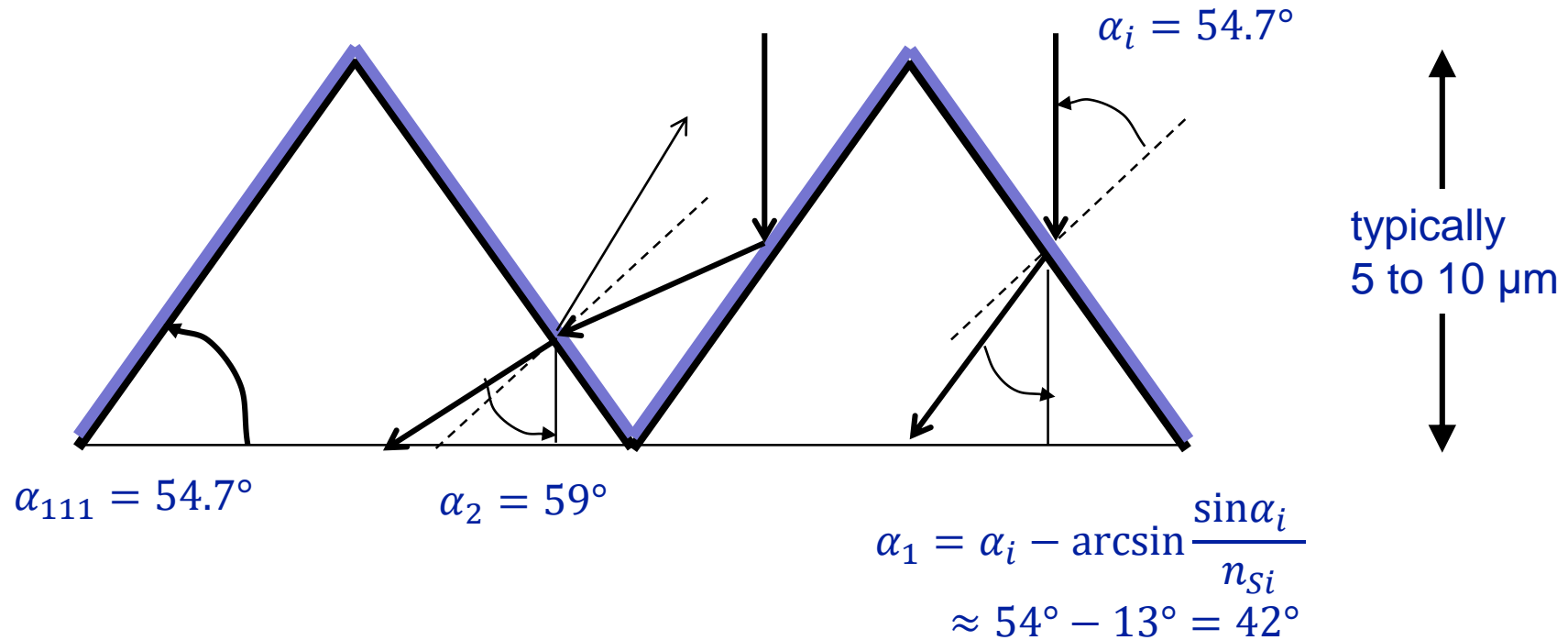
Redfield, APL (1974)

# EPFL Natural texture: 111 facets of 100 surface



Ideal facet angle: 54.7°

# Reduced reflection by surface texture

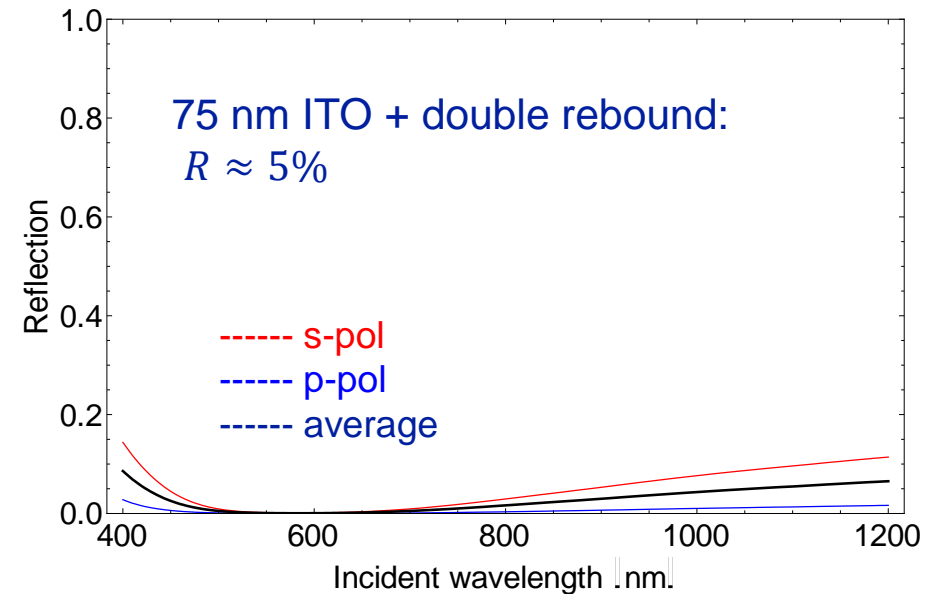
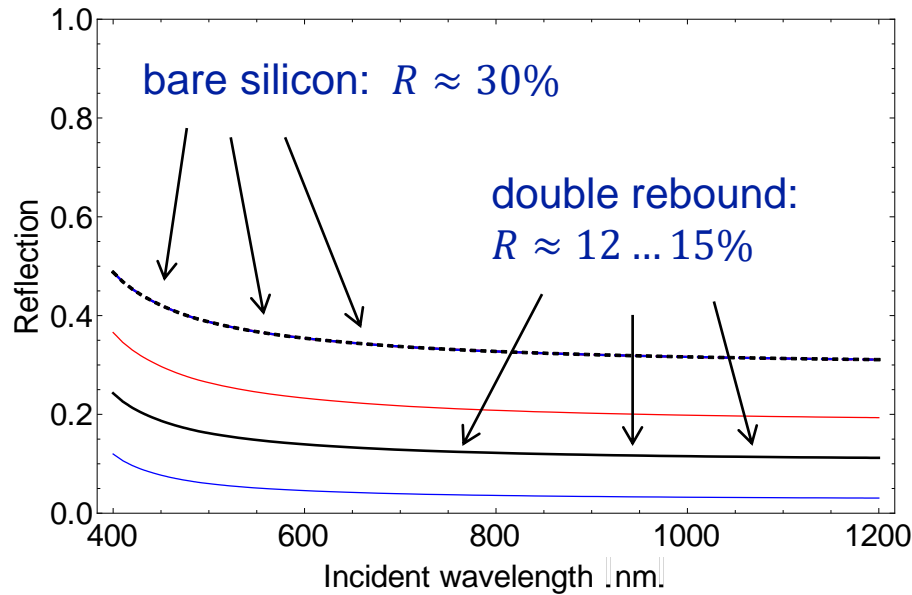


If facet angle  $>45^\circ$ : forward scattering with second hit (double rebound)

# EPFL AR properties

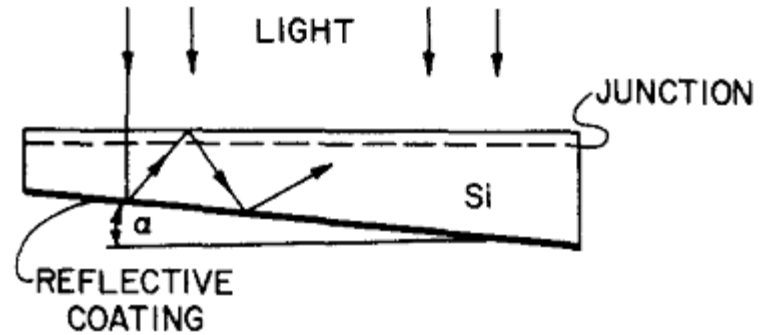
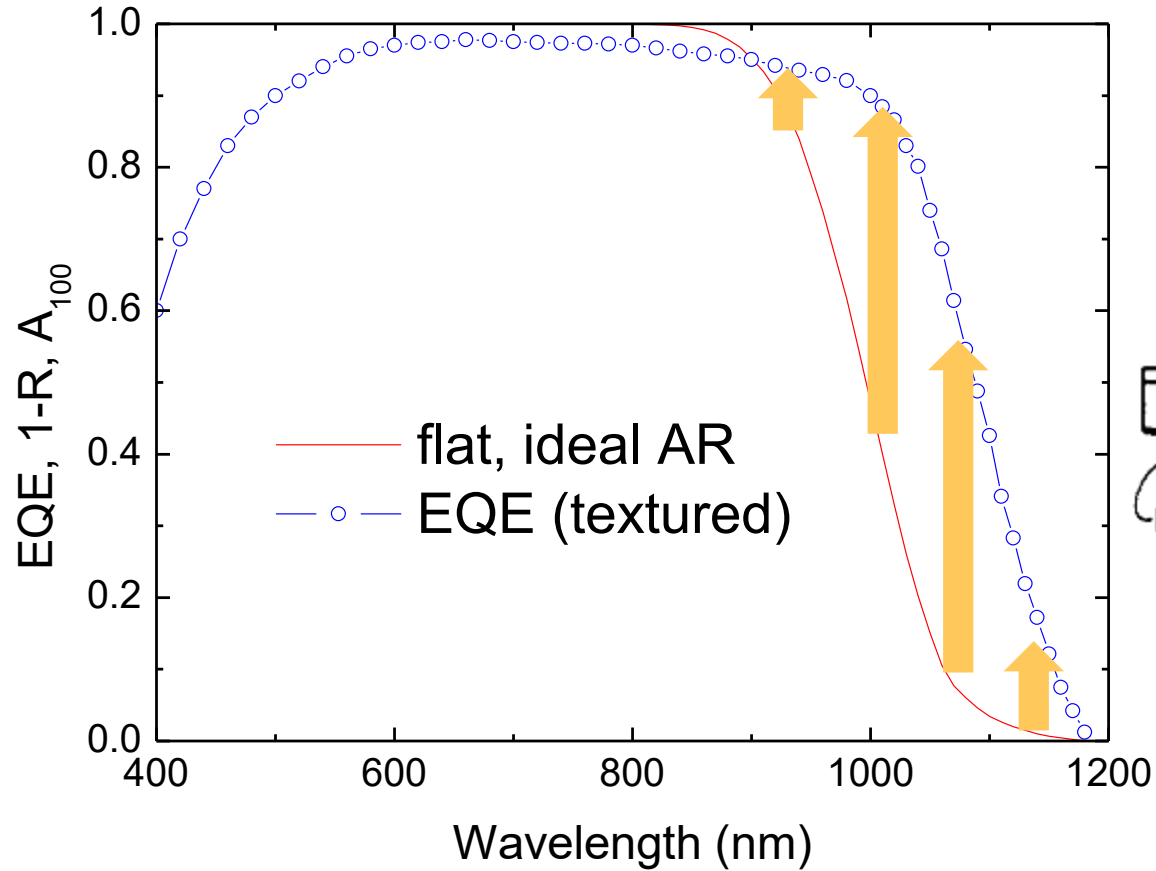
AR coating: depending on technology

- $\text{SiO}_2/\text{Si}_3\text{N}_4$ : passivation for diffused p-n junction cells
- ITO: electric contact in heterojunction cells



Texture and passivation/contact are mandatory => AR is “free”  
Any additional feature incurs cost (e.g. double AR coating, etc.)

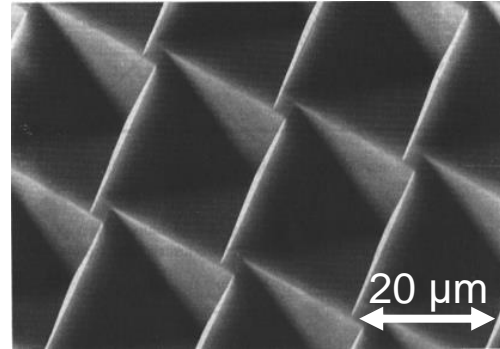
# Enhanced absorption by surface texture



concept:: Redfield, APL (1974)  
data: e.g. Holman, JAP (2013)

# EPFL Light trapping in (thick) c-Si cells

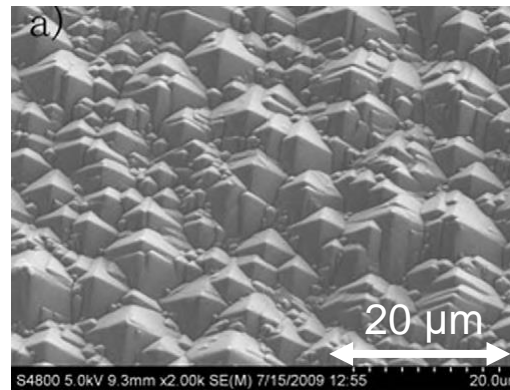
c-Si high eff. cells:  
inverted pyramids  
(lithography: costly)



Apply geometric ray  
tracing to one square

from Goetzberger, Sonnenenergie (1997)

mc-Si low cost option:  
random etch

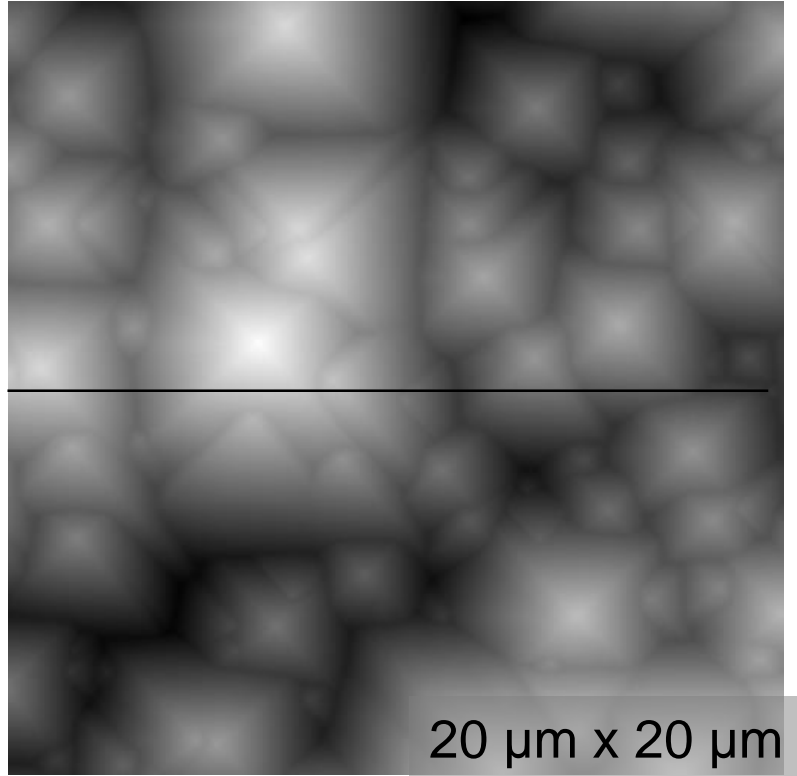


Need to describe  
random scattering

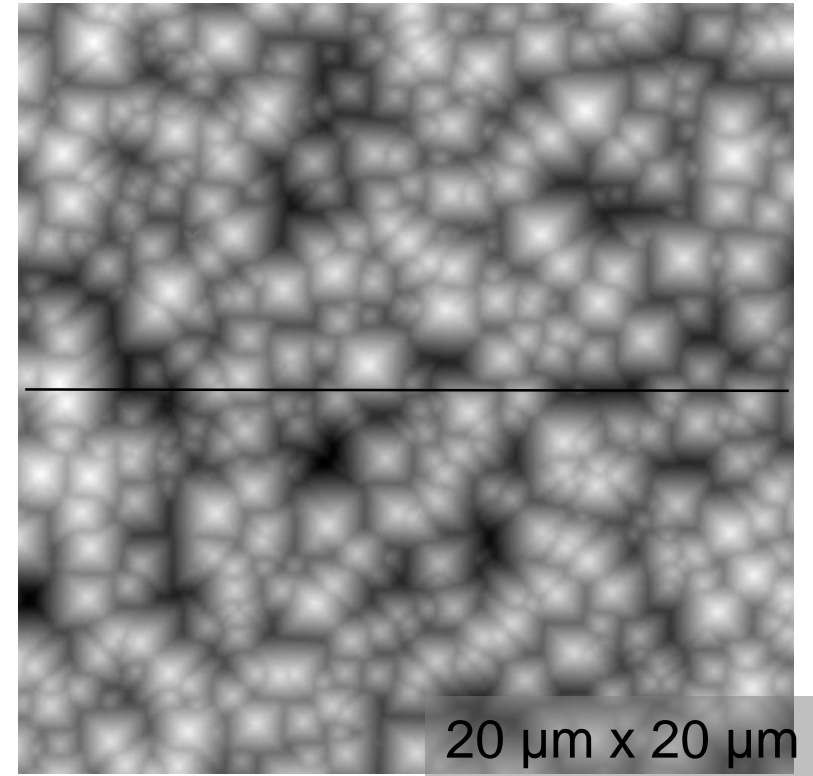
from Xiao, Appl. Surf. Sci. 257, p472, (2010)



# State of the art texture on mono-Si(100)



typical texture for HIT solar cells

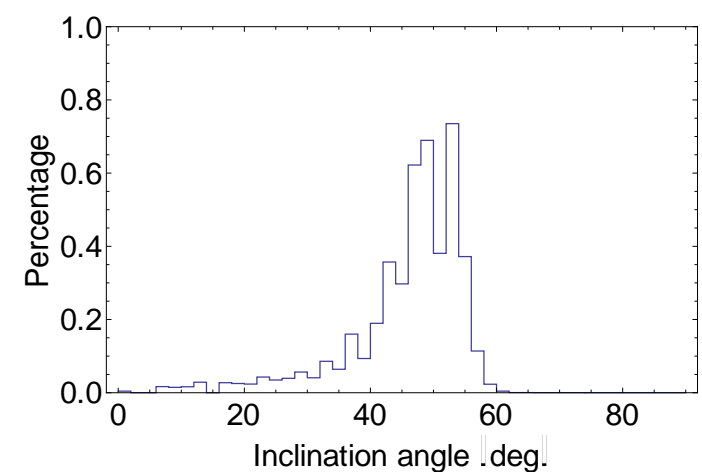
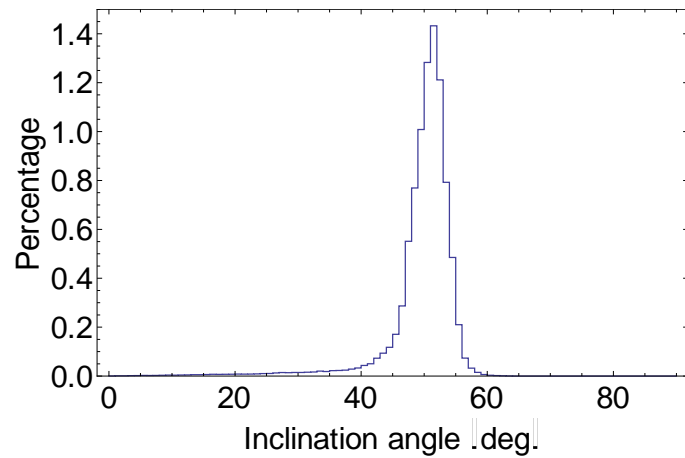
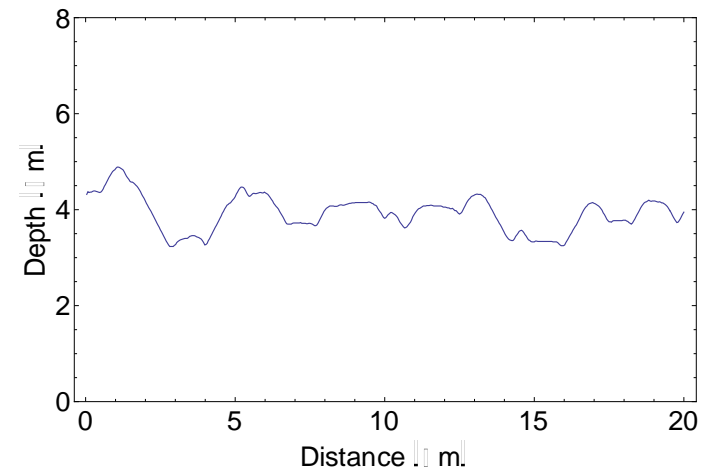
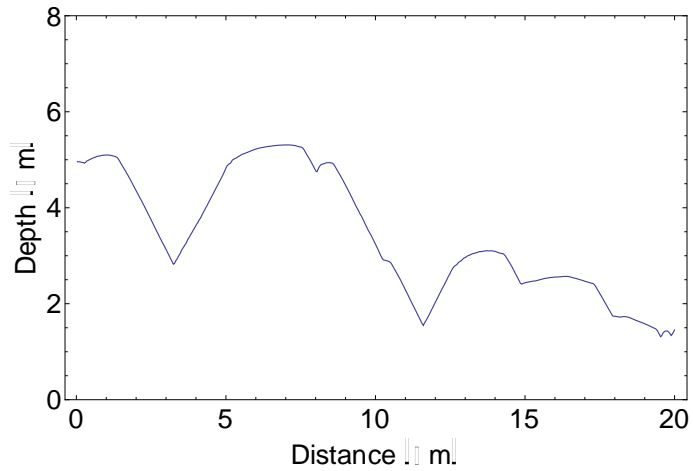


test structure w. small features

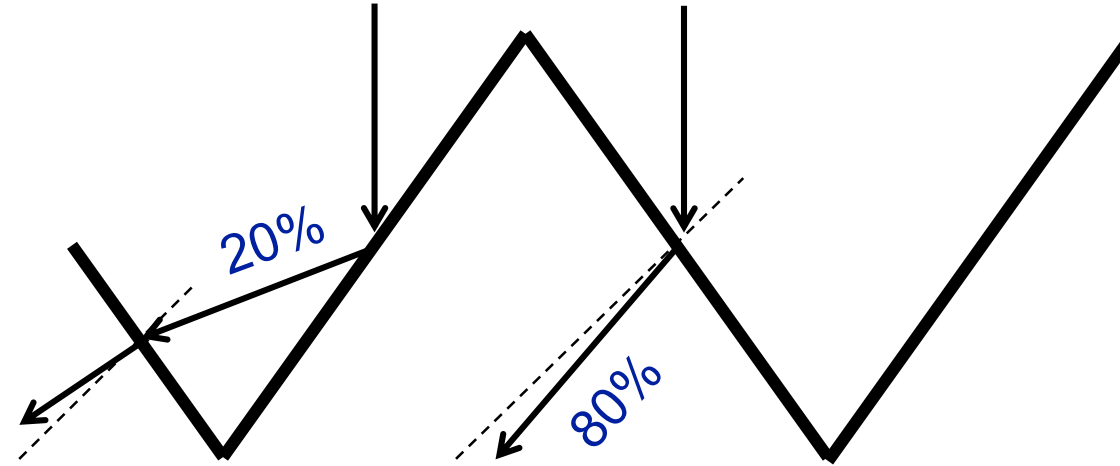
smaller feature size interesting for thin wafers ( $<100 \mu\text{m}$ ) or exfoliated epi-layers

Haug, Opt. Express (2017)

# State of the art texture on mono-Si(100)



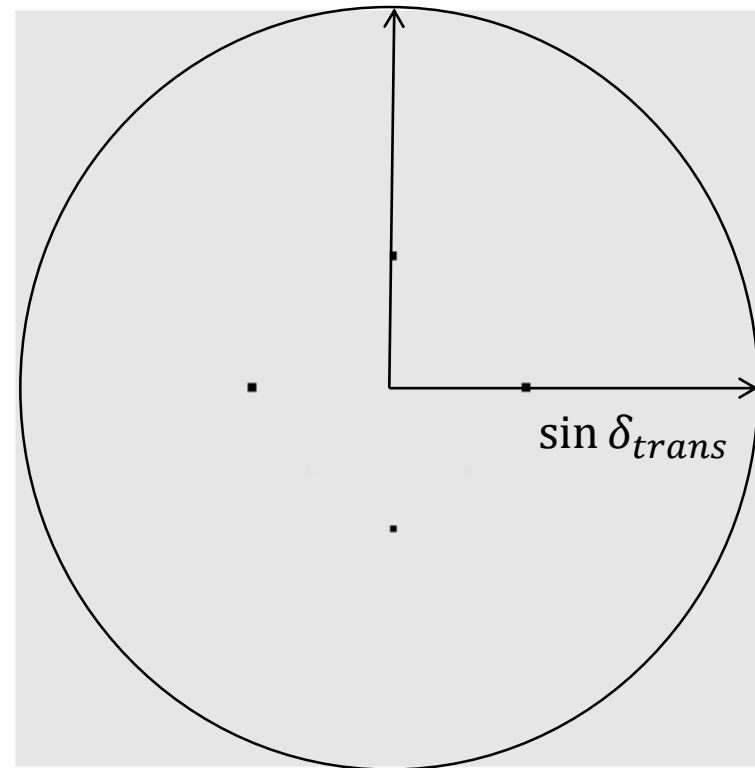
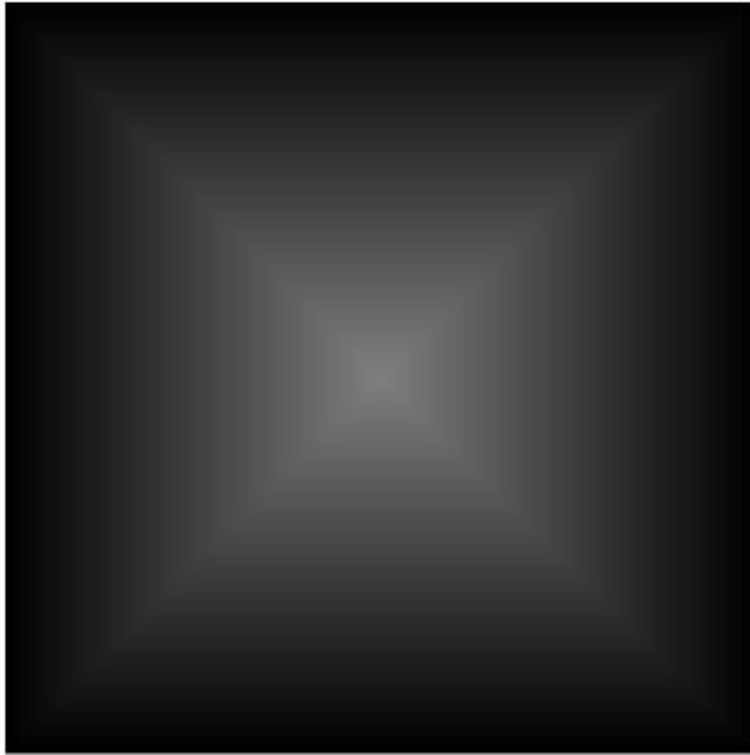
close to theoretical facet angle ( $54.7^\circ$ )



large pyramids (> 5  $\mu\text{m}$ ):  
adequately treated by ray tracing

$$\vec{t} = \frac{n_1}{n_2} \vec{i} + \left( \frac{n_1}{n_2} \cos \theta_i - \sqrt{1 - \left( \frac{n_1}{n_2} \right)^2 (1 - \cos^2 \theta_i)} \right) \vec{n}$$

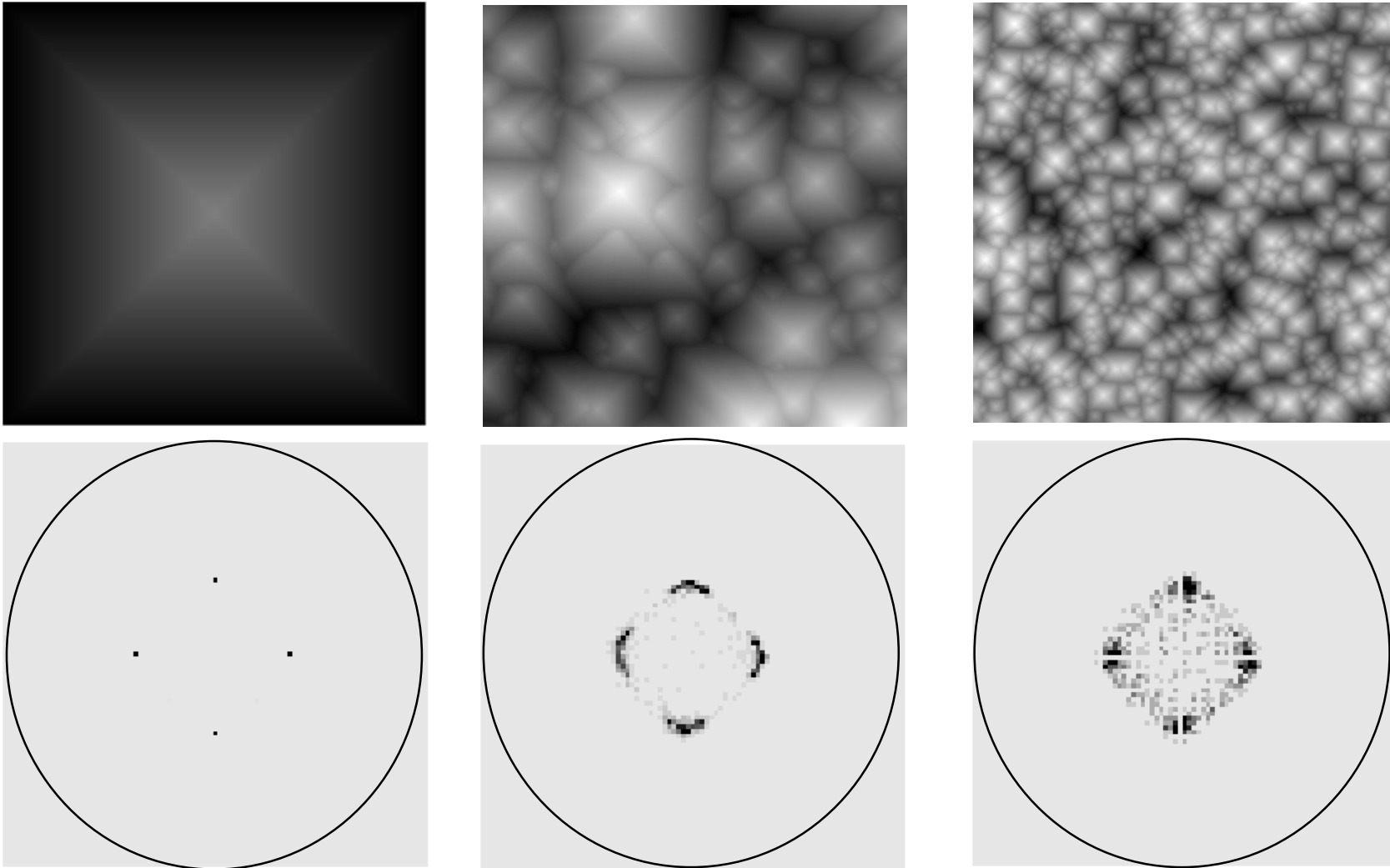
# EPFL Ray tracing



Example: 1000 rays, reflective boundaries,  $n_{543 \text{ nm}} = 1.5$  (typical polymers)

Circle separates propagating from evanescent modes (for later use)

# EPFL Ray tracing

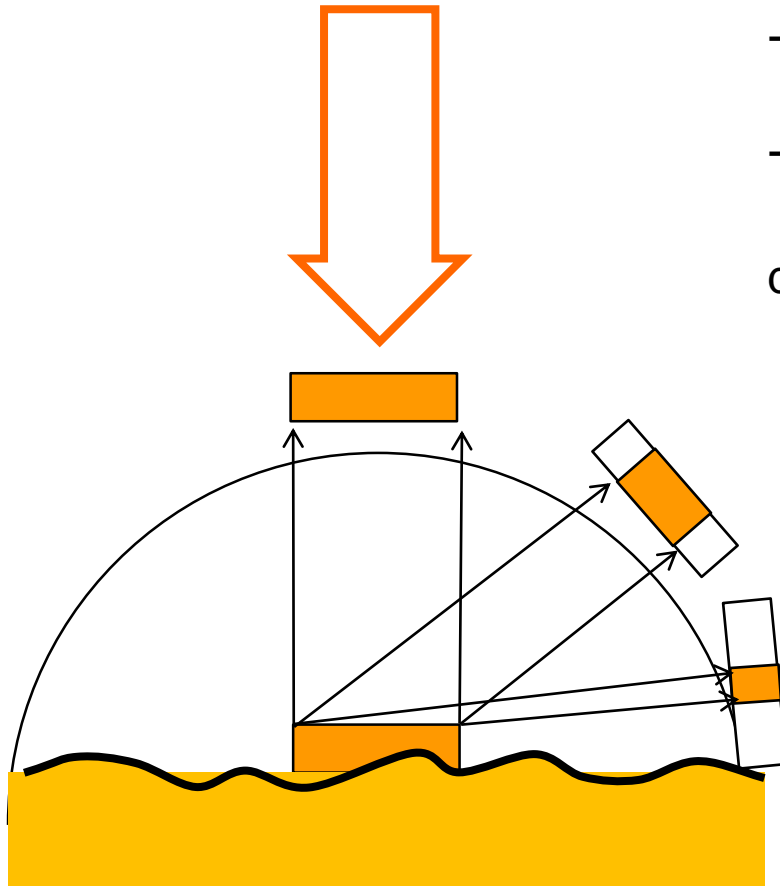


# EPFL Isotropic scattering (Lambertian)

Concept:

- surface scatters equally in all directions (e.g. white paper, projection screen, etc.)
- angular dependence because of projection

described by:  $ARS_{Lambert} = \frac{1}{\pi} \cos \theta$



Lambert, Photometria (1760)

Prolongation of an oblique path

$$d' = d / \cos \theta$$

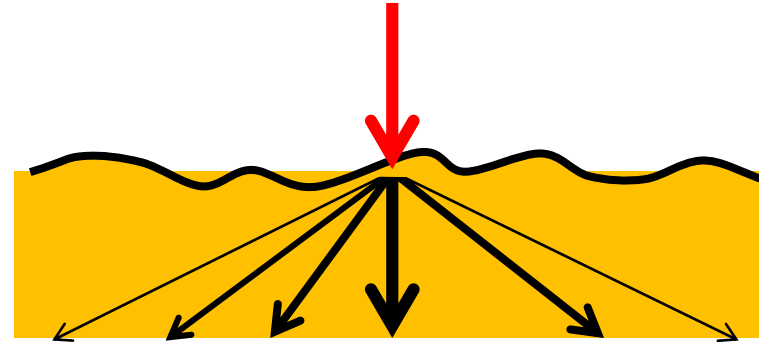
Average prolongation

$$d_{av} = \int d' \cdot ARS_{Lambert} d\Omega$$

$$= 2\pi \cdot \int \frac{d}{\cos \theta} \cdot \frac{\cos \theta}{\pi} \cdot \sin \theta d\theta = 2 \cdot d$$

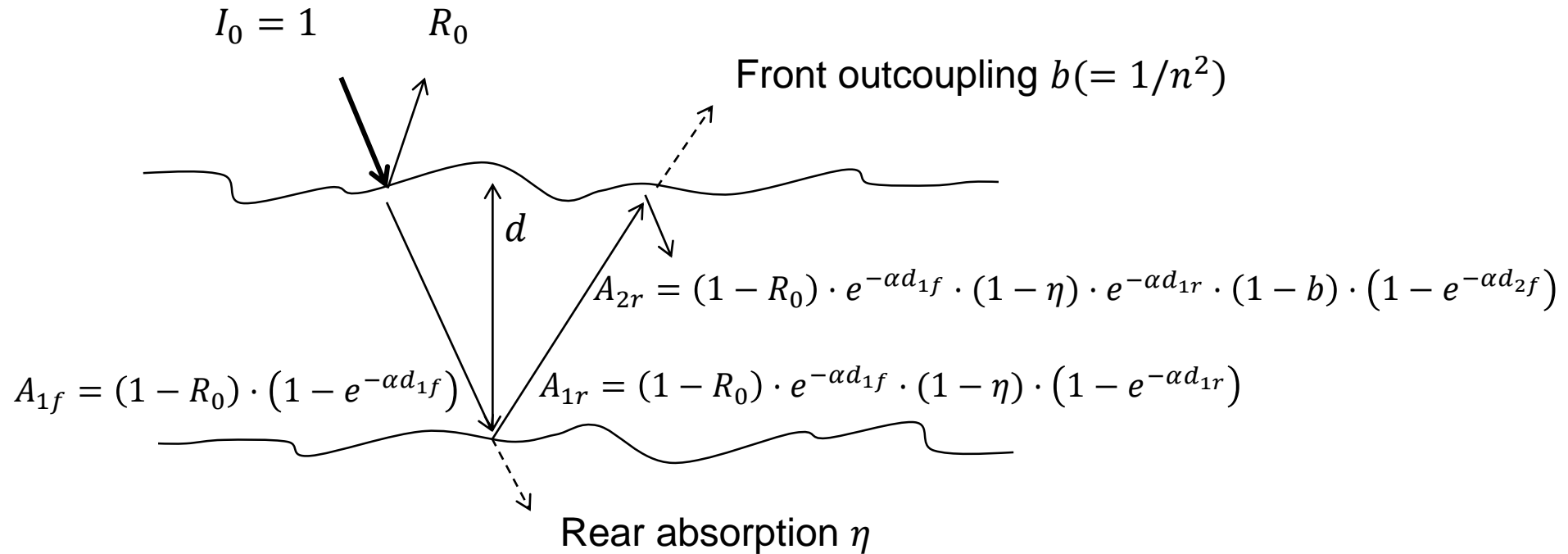
weighting factor, probability to find angle btw.  $\theta$  and  $\theta + d\theta$

length of oblique path



# EPFL A very simple (but illustrative) analytic model

Sum up absorption upon bouncing forth and back



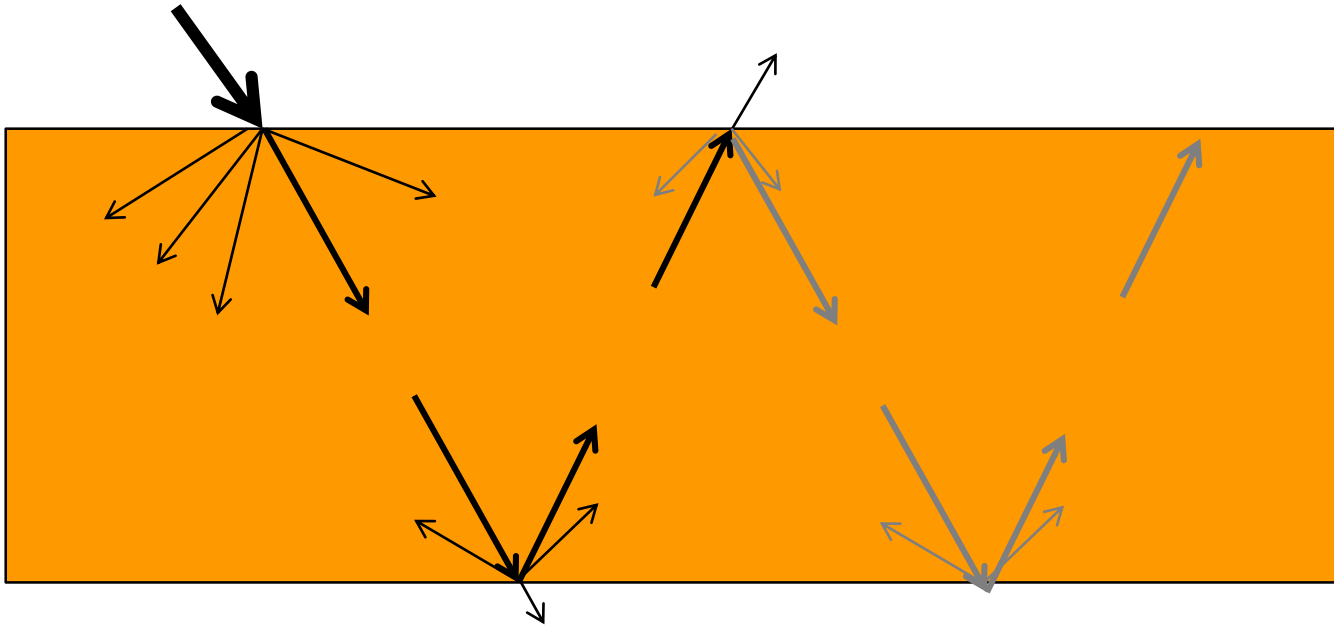
$d_{1f}$ : average length after 1<sup>st</sup> scattering event

$d_{1r}$ : average length after scattering at rear

Deckman, APL (1982)  
Boccard, APL (2012)



# Geometric series with scattering



Add absorption after each rebound (Lambertian path length,  $x2$ )

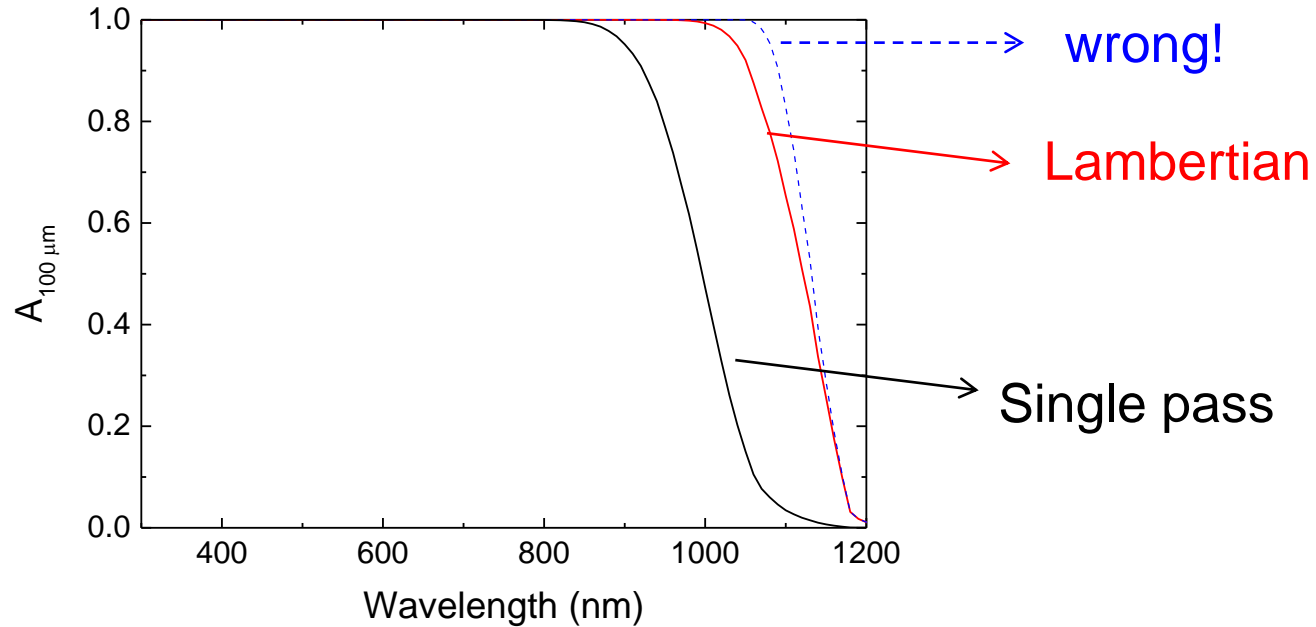
$$\begin{aligned}
 A &= \sum_{k=0}^{\infty} \underbrace{[(1 - e^{-2\alpha l}) + e^{-2\alpha l}(1 - \eta)(1 - e^{-2\alpha l})]}_{A_{\text{double pass}}} \cdot \underbrace{[e^{-4\alpha l}(1 - \eta)(1 - 1/n^2)]^k}_{\text{Attenuation}} \\
 &= \frac{1 - \eta e^{-2\alpha l} - (1 - \eta)e^{-4\alpha l}}{1 - (1 - \eta)e^{-4\alpha l} + [(1 - \eta)/n^2]e^{-4\alpha l}} \\
 &\approx 4n^2\alpha l \quad \text{if: } \eta = 0, \alpha l \ll 1
 \end{aligned}$$

Deckman, APL (1983)

Boccard, APL (2012)

Yablonovitch, TED (1982)

# EPFL Upper limit of light trapping

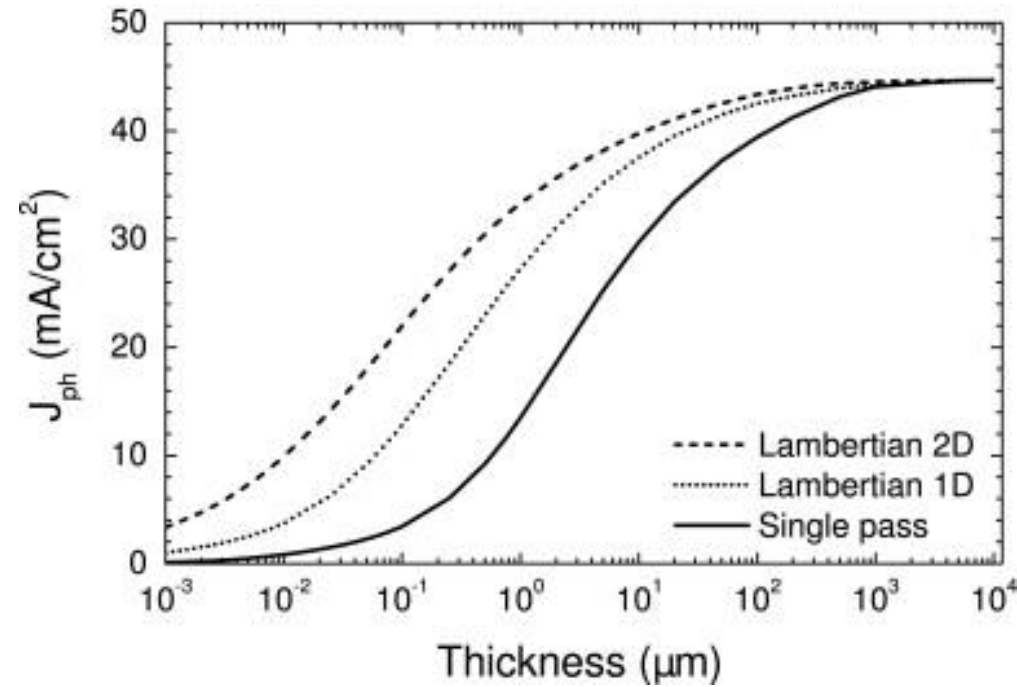


Single pass (100  $\mu\text{m}$ ):  $A = 1 - e^{-\alpha l}$

Lambertian enhancement: 
$$A = \frac{1 - e^{-4\alpha l}}{1 - e^{-4\alpha l} + 1/n^2 \cdot e^{-4\alpha l}}$$

Attention, Yablonoitch's formula is often used wrongly:  $A = 1 - e^{-\alpha \cdot 4n^2 l}$

# EPFL Maximum photocurrent



70 to 100 μm sufficient for almost-ideal absorption

Issue: most surfaces don't scatter Lambertian  
maybe for some, but not for all wavelengths

Andreani, SolMat (2015)

# EPFL Wavelength dependence: recall radar science

Incoherent scattering intensity, parameterize via rms roughness

$$R_{spec} = R_0 \cdot \exp\left\{-\left(4\pi \cdot \sigma_{rms} / \lambda\right)^2\right\}$$

$$R_{diff} = R_0 - R_{spec}$$

Davis, Proc. Inst. Electr. Eng. 101, p209, (1951)

Rice, Commun. Pure. Appl. Math. 4, p351 (1954)

Bennett, J. Opt. Soc. Am. 51, p123, (1961)

Haze:

$$H_R = R_{diff} / R_{tot}$$

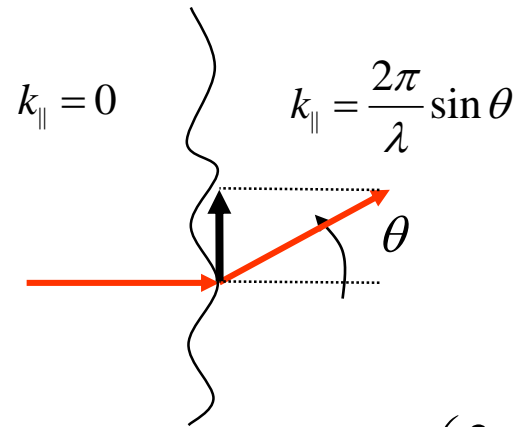
$$H_T = T_{diff} / T_{tot} = 1 - \exp\left\{-\left(2\pi / \lambda \cdot \sigma_{rms} \cdot |n_1 \cos \theta_i - n_2 \cos \theta_t|\right)^2\right\}$$

Needs: assumption or surface profile data for  $\sigma_{rms}$

Carniglia, Opt. Eng. 18, p104, (1979)

# Angular intensity distribution (ARS)

- Assumed (e.g. Lambertian,  $ARS_L = 1/\pi \cdot \cos \theta$ )
- Measure ARS, project to other interfaces and wavelengths
- Estimate momentum change via power spectral density  $g(k)$

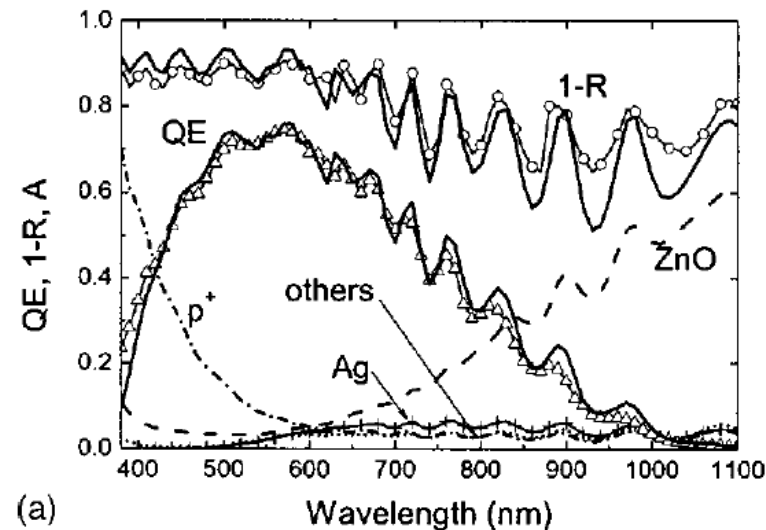
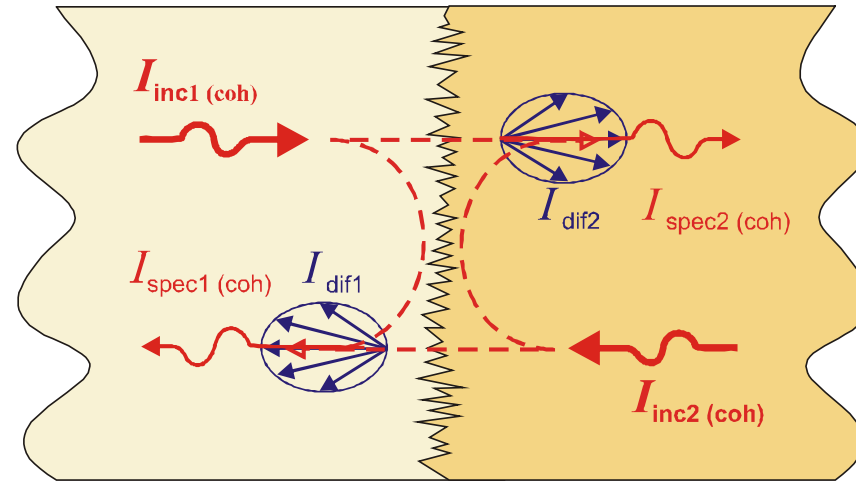


$$ARS(\theta) \sim g(k_x) \cdot \cos \theta = g\left(\frac{2\pi}{\lambda} \sin \theta\right) \cdot \cos \theta$$

Needs: assumption or surface profile data for  $g(k)$

# EPFL Modelling of devices with textured interfaces

- light scattering at interfaces:
  - haze (diff/total)
  - ARS (angle resolved scattering)
- propagation within layer:
  - specular: coherent
  - diffuse: incoherent
- use eff. path length for absorption



(a) Springer, J. Appl. Phys. 2004  
Krc, Thin Solid Films 2003  
Zeman, J. Appl. Phys. 2000  
Santbergen, Sol. En. Mat, 2010

# Issue: model uses tuneable parameters

Haze:

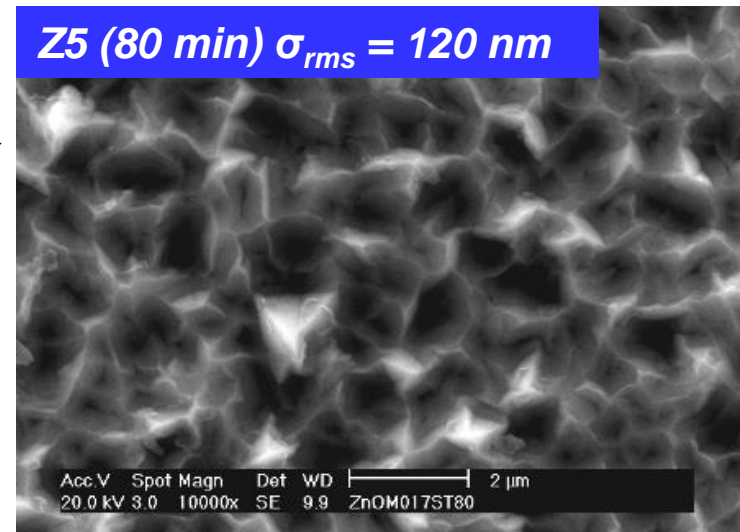
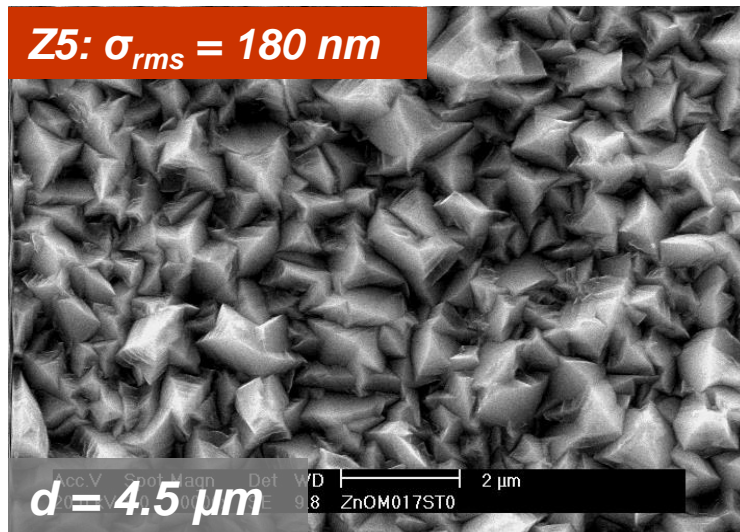
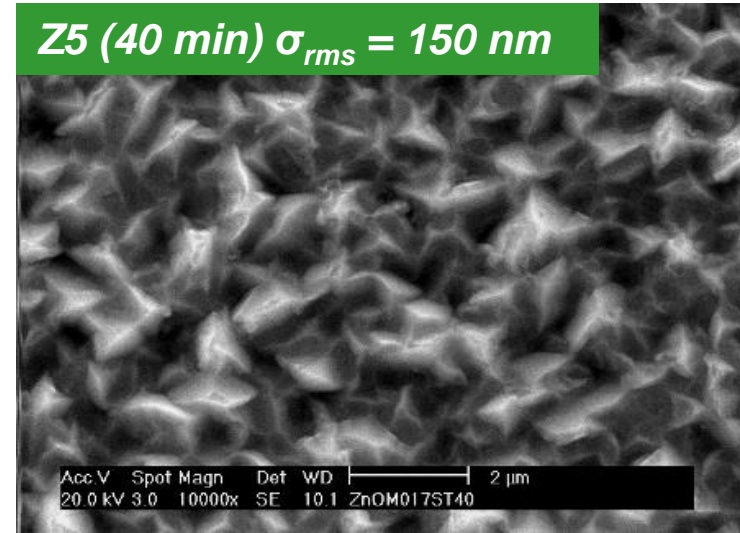
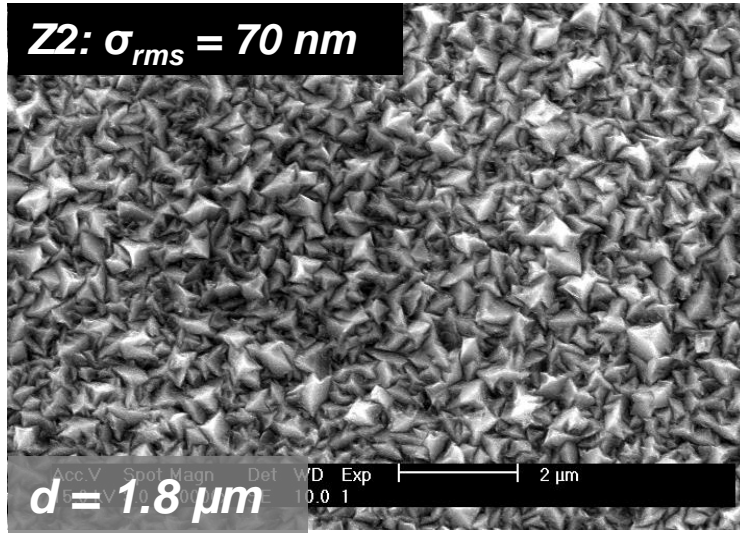
$$H_T = T_{\text{diff}} / T_{\text{tot}} = 1 - \exp\left\{-\left(2\pi / \lambda \cdot \sigma_{\text{eff}} \cdot \left|n_1 \cos \theta_i - n_2 \cos \theta_t\right|\right)^\delta\right\}$$

effective roughness  $\sigma_{\text{eff}}$  usually less than AFM roughness  $\sigma_{\text{rms}}$   
exponent  $\delta$  higher than two, e.g. 3 or 3.5

ARS:

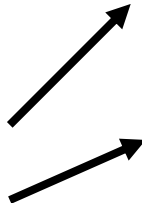
Assumptions poorly justified

# Examples: texture of LPCVD-ZnO



Thickness

Plasma treatment





# Description of haze: scalar theory

$$H_T = T_{\text{diff}} / T_{\text{tot}} = 1 - \exp\left\{-\left(2\pi / \lambda \cdot \sigma_{\text{rms}} \cdot |n_1 \cos \theta_i - n_2 \cos \theta_t|\right)^\delta\right\}$$

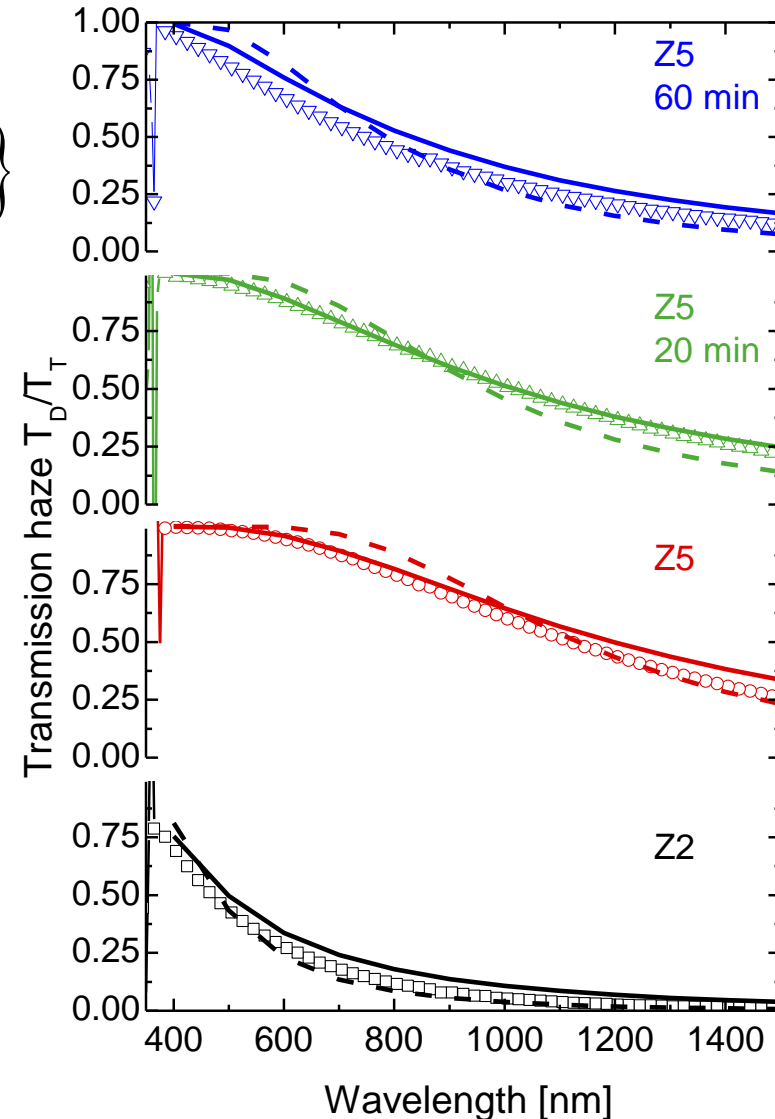
Exponent  $\delta$ :

- scattering theory:  $\delta = 2$  →
- literature (empiric):  $\delta = 3$  - - - →

Roughness  $\sigma$ :

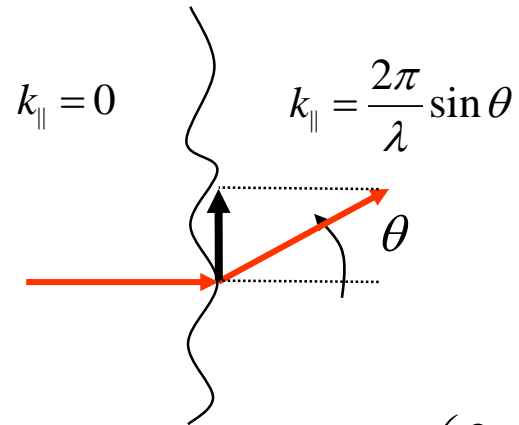
- shown:  $\sigma_{\text{rms}} = \sigma_{\text{AFM}}$
- literature (empiric):  $\sigma_{\text{rms}} < \sigma_{\text{AFM}}$

Not applicable to wide spectral range  
Changes of  $\delta$  and  $\sigma_{\text{rms}}$  remain empiric



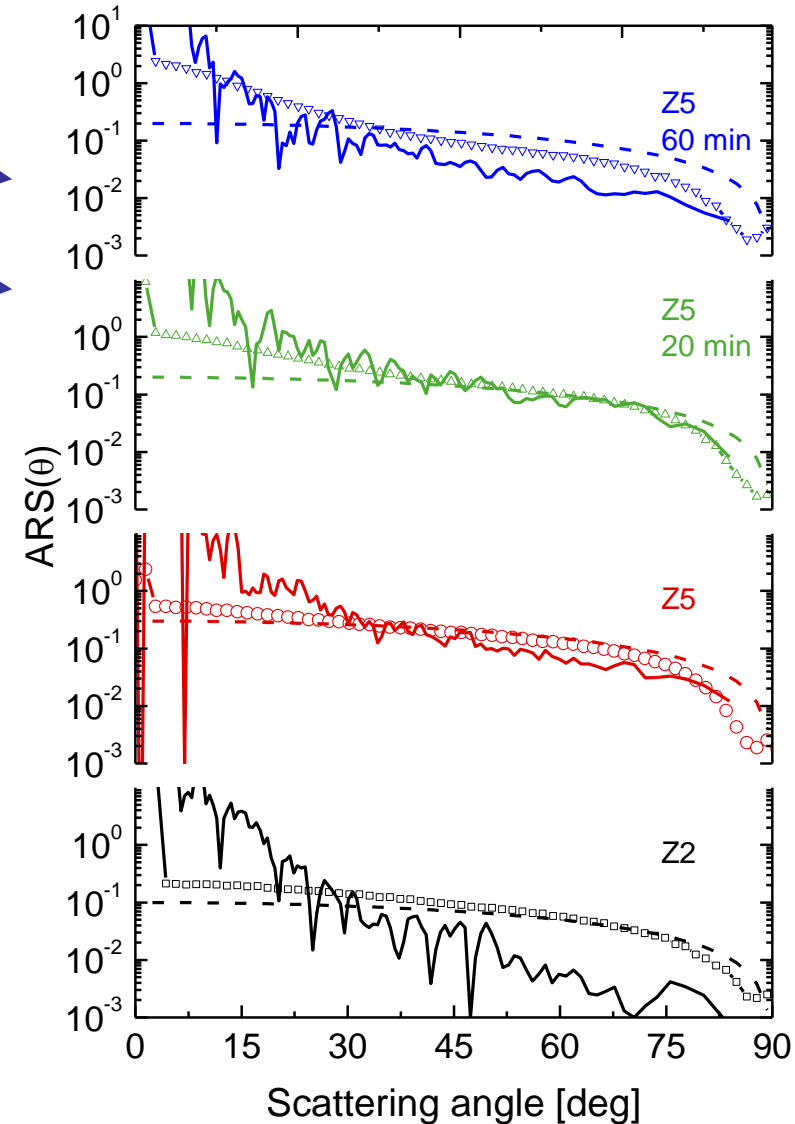
# Angular distribution

- Measured (symbols: 543 nm)
- Assumed (e.g. Lambertian)
- Estimate momentum change via power spectral density  $g(k)$

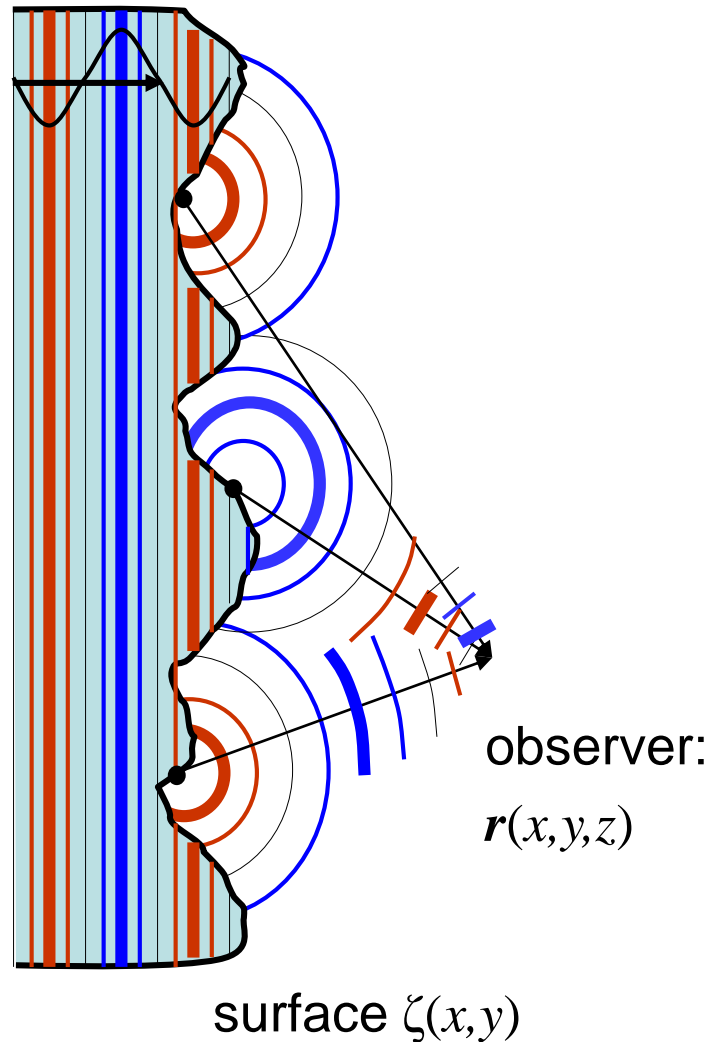


$$ARS(\theta) \sim g(k_x) \cdot \cos \theta = g\left(\frac{2\pi}{\lambda} \sin \theta\right) \cdot \cos \theta$$

- Lambertian too high for high angles
- PSD too high for low angles
- Both: no prediction of specular beam



# Alternate approach: Fourier theory



Huygens principle:

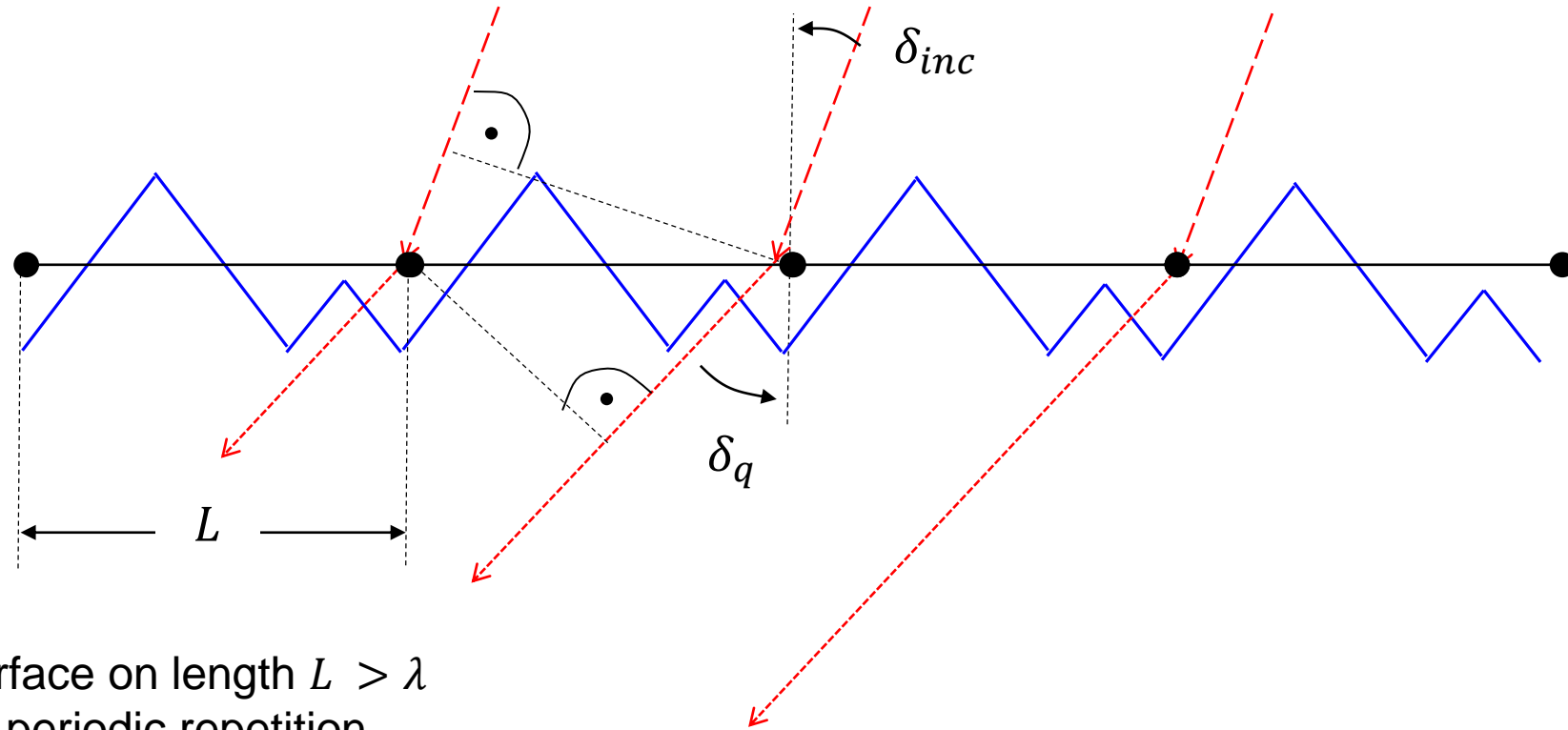
consider field at  $\mathbf{r}(x,y,z)$  as superposition of spherical waves emitted from each point  $\zeta(x,y)$  with local phase

Two choices of aperture function  $U_0(x,y)$ :

- **Amplitude modulation**  
for apertures or grey-levels, reproduces PSD (not applicable, ZnO is transparent)
- **Phase modulation**  
more likely, but how to define?

e.g. Goodman, Fourier Optics

# EPFL Fourier scattering model

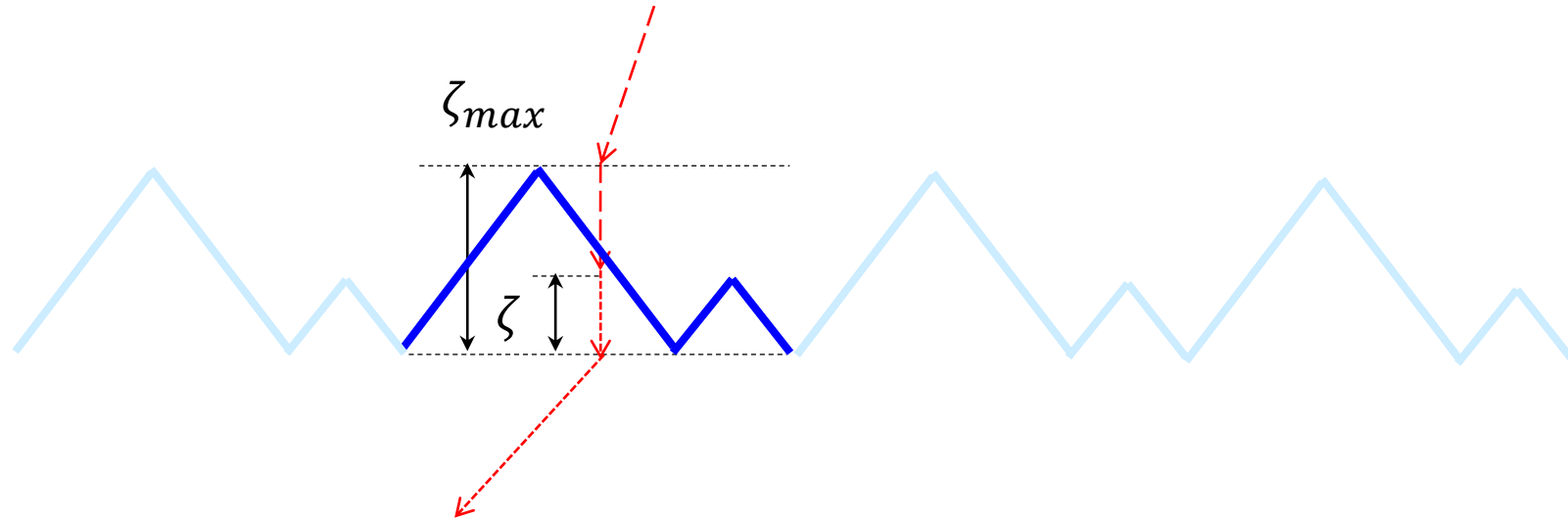


Scan surface on length  $L > \lambda$   
Assume periodic repetition  
Periodicity  $L$  diffracts into orders  $q$   
Angles given by grating equation

$$n_1 \cdot \sin \delta_{inc} - n_2 \cdot \sin \delta_q = q \cdot \lambda / L$$

Goodman, Fourier Optics

# EPFL Diffraction intensity



Fourier transform (for discrete 1D-data):  $f_q = \frac{1}{\sqrt{N}} \sum_{p=1}^N U_t \cdot e^{-2\pi i \cdot p \cdot q / N}$

$U_t(\zeta(p/L))$ : phase changing pupil function  $U_0 \cdot e^{ik_0[\zeta \cdot n_1 + (\zeta_{max} - \zeta) \cdot n_2]}$

Intensity going into  $q$ -th order:  $\sim f_q f_q^*$  (more precisely: radiance)

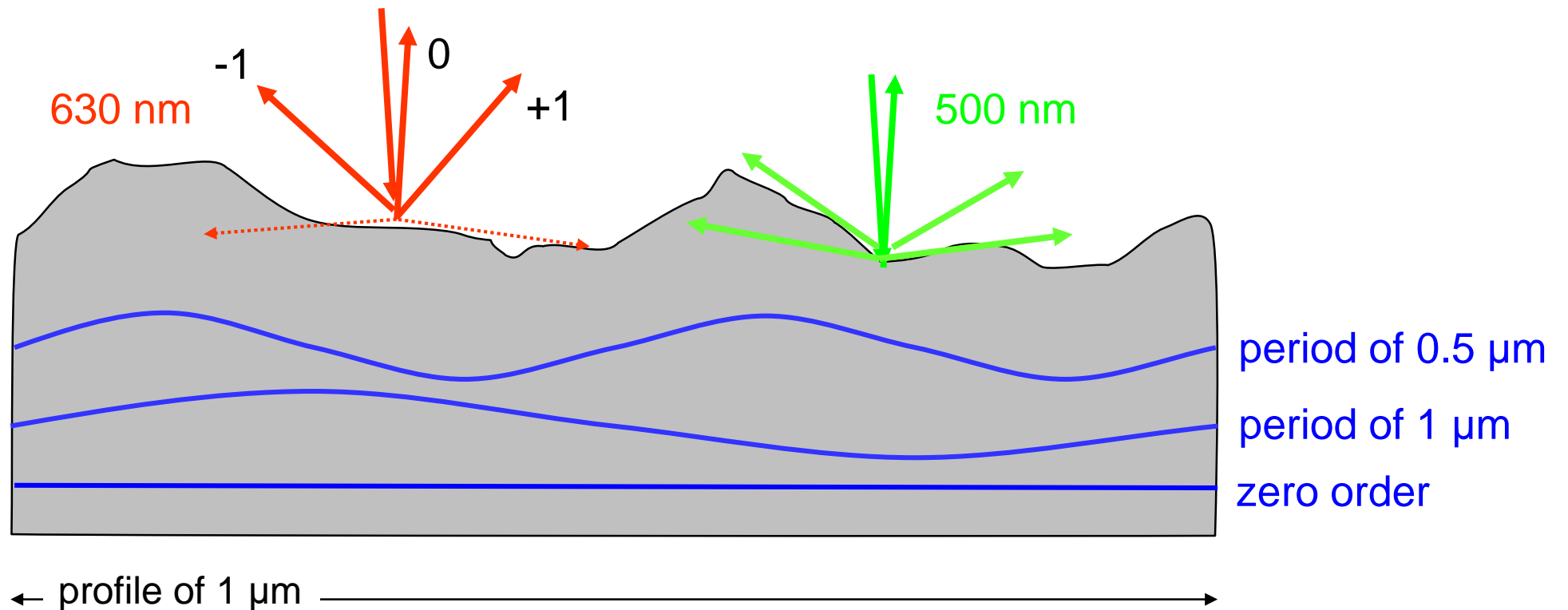
Needs: AFM profile and  $n_1, n_2$ ; no empiric parameters!

Harvey, Appl. Opt. (1999)  
Dominè, JAP (2010)

# Propagating and evanescent modes

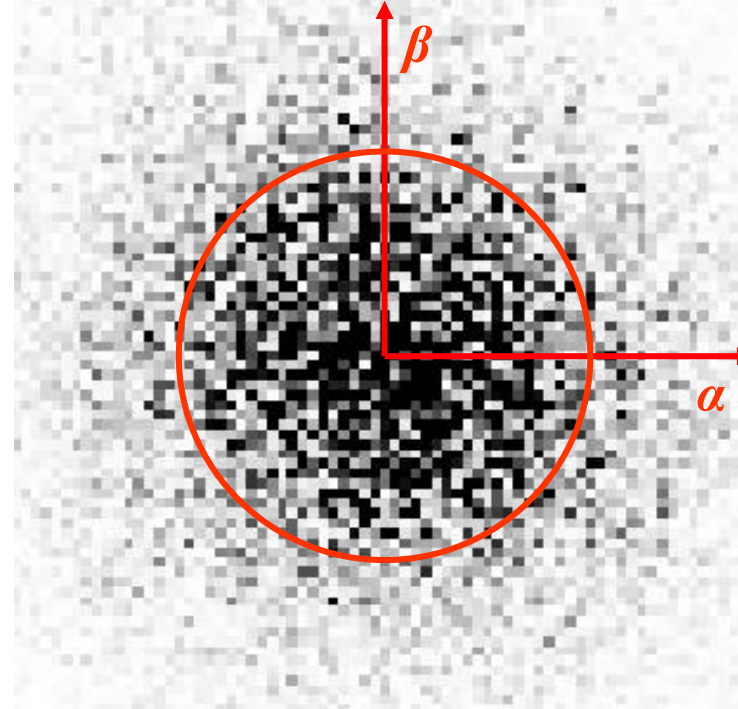
Fourier theory predicts mode amplitudes,  
including zero order (specular beam) and evanescent modes

Grating analogy:  $\lambda >$  period: specular reflection, no diffraction



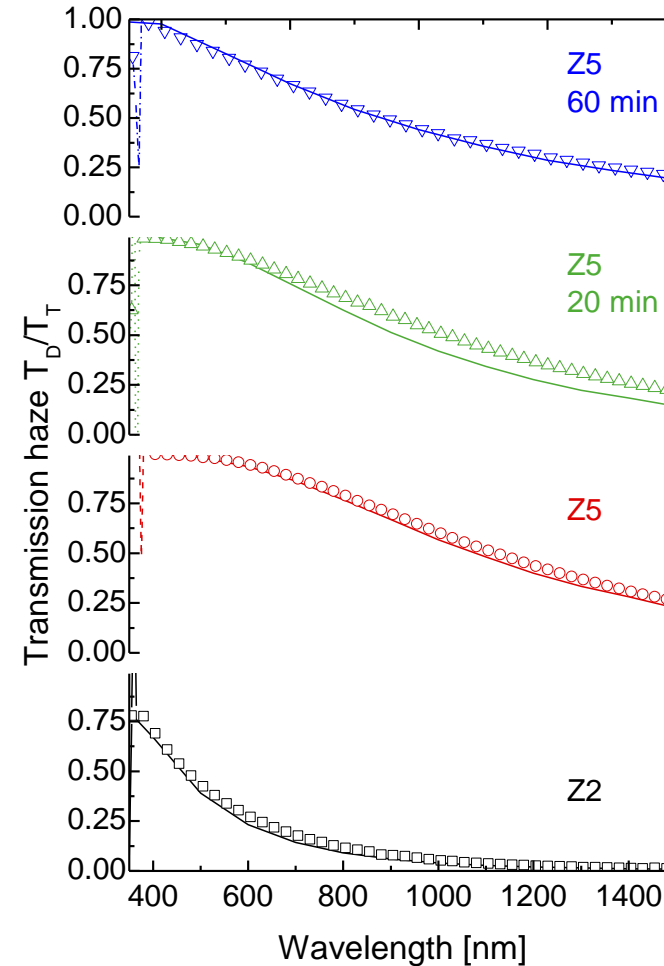
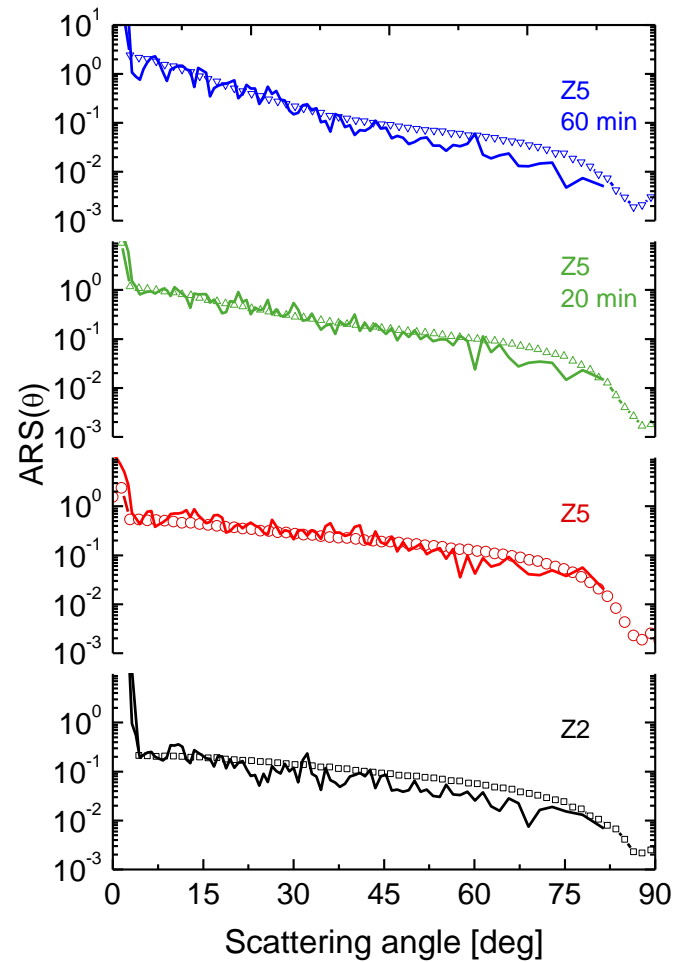
# EPFL Normalization procedure

- Find diffraction angles  $>90^\circ$   
convenient index scaling of FFT:  
direction cosine space
- distribute intensity between  
propagating modes only
- ARS: cut along axis, possibly  
polar average
- Haze: ratio of value at origin to  
everything within unit circle



Harvey, Proc. SPIE (1989)  
Domine, JAP (2009)

# Comparison to experiment



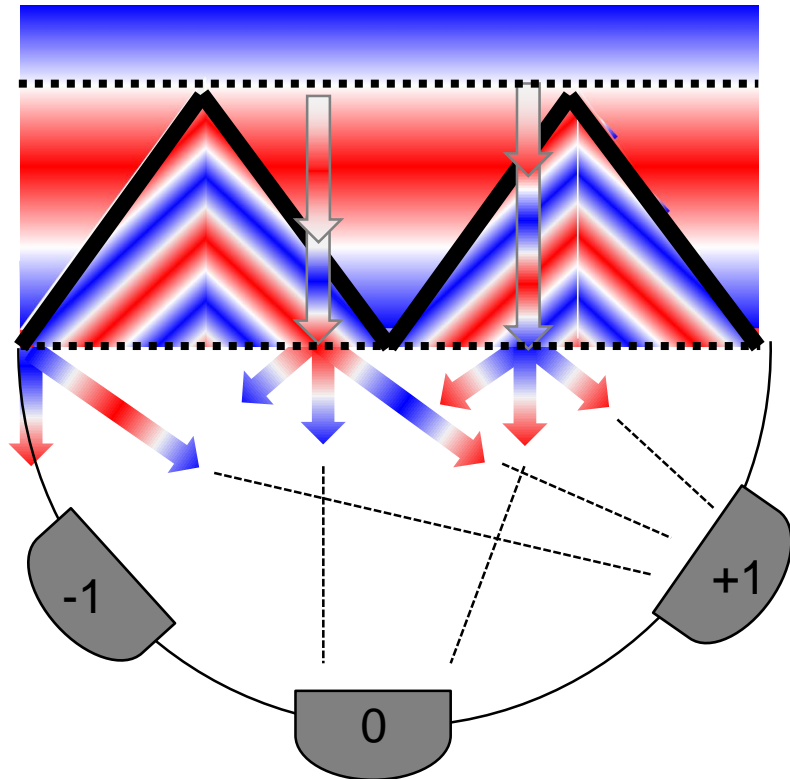
Excellent agreement for ARS at 514 nm and for spectral haze

Domine, JAP (2009)

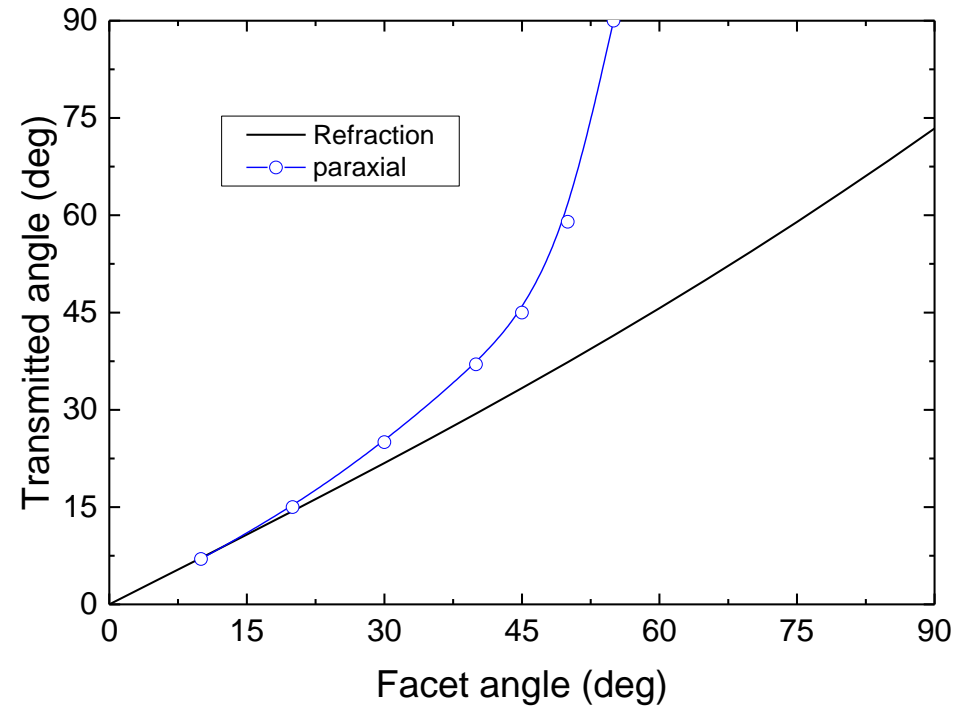


# Caveat: paraxial error for large angles

Test: apply to large wedge  
( $> 10 \times \lambda$ , avoid scattering)

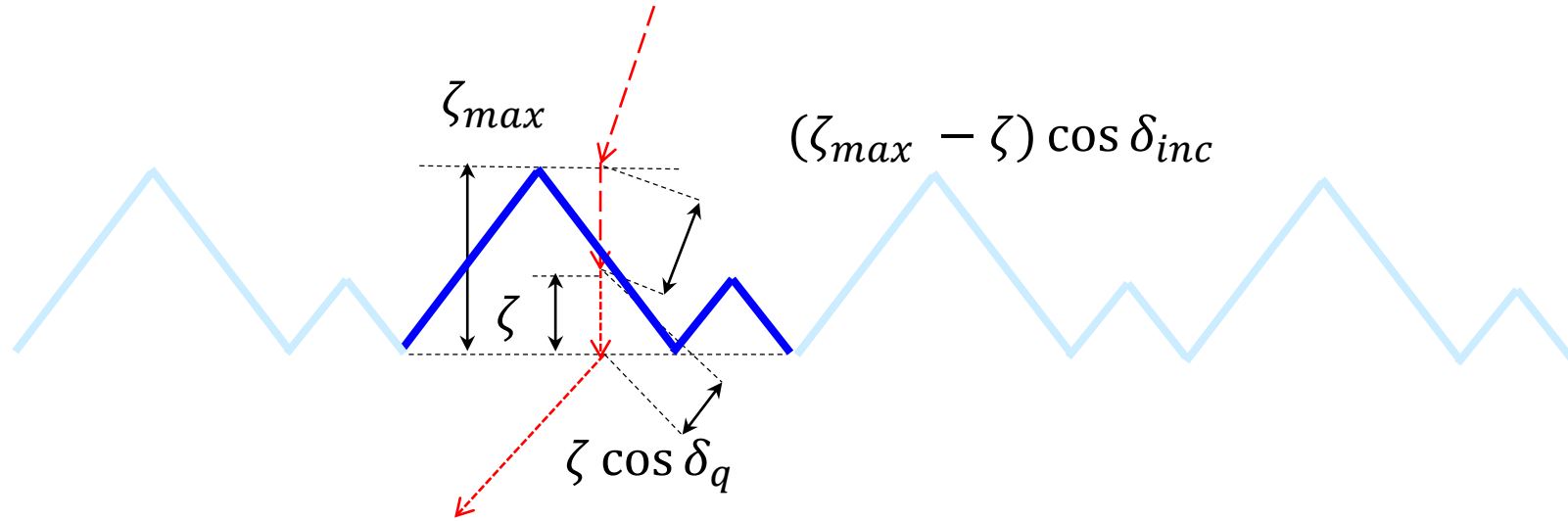


Underlying reason: replacing roughness zone with flat phase screen ignores interference within roughness



D. Dominè, PhD thesis (2009)

# EPFL Removal of paraxial error

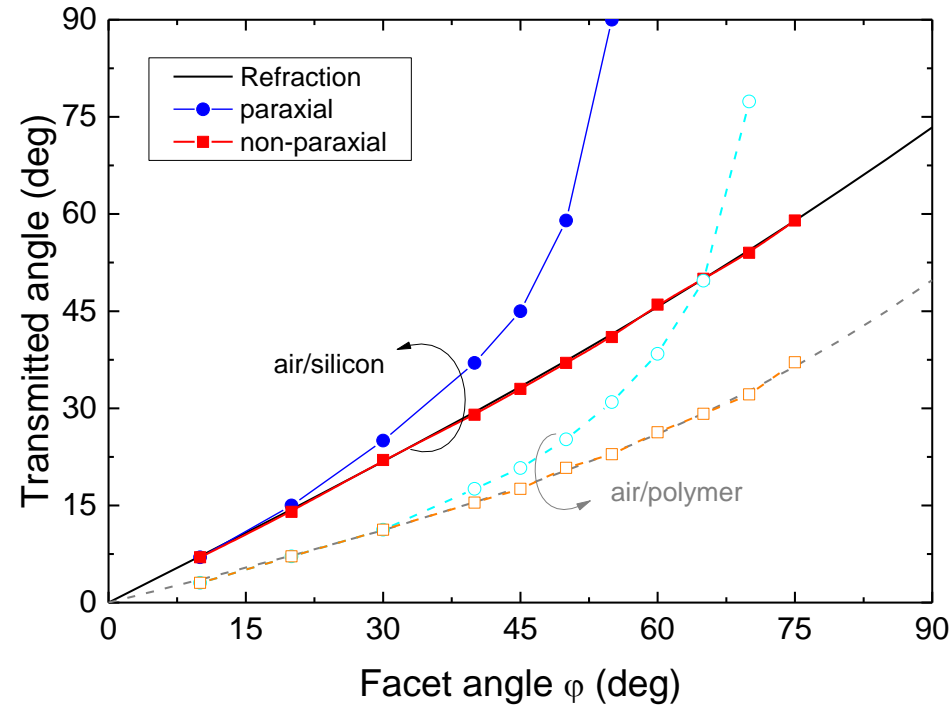


Use projections of surface profile along incoming and outgoing beams

$$\Delta\phi = k_0(n_1 \cos \delta_{inc} + n_2 \cos \delta_q) \cdot z(x, y)$$

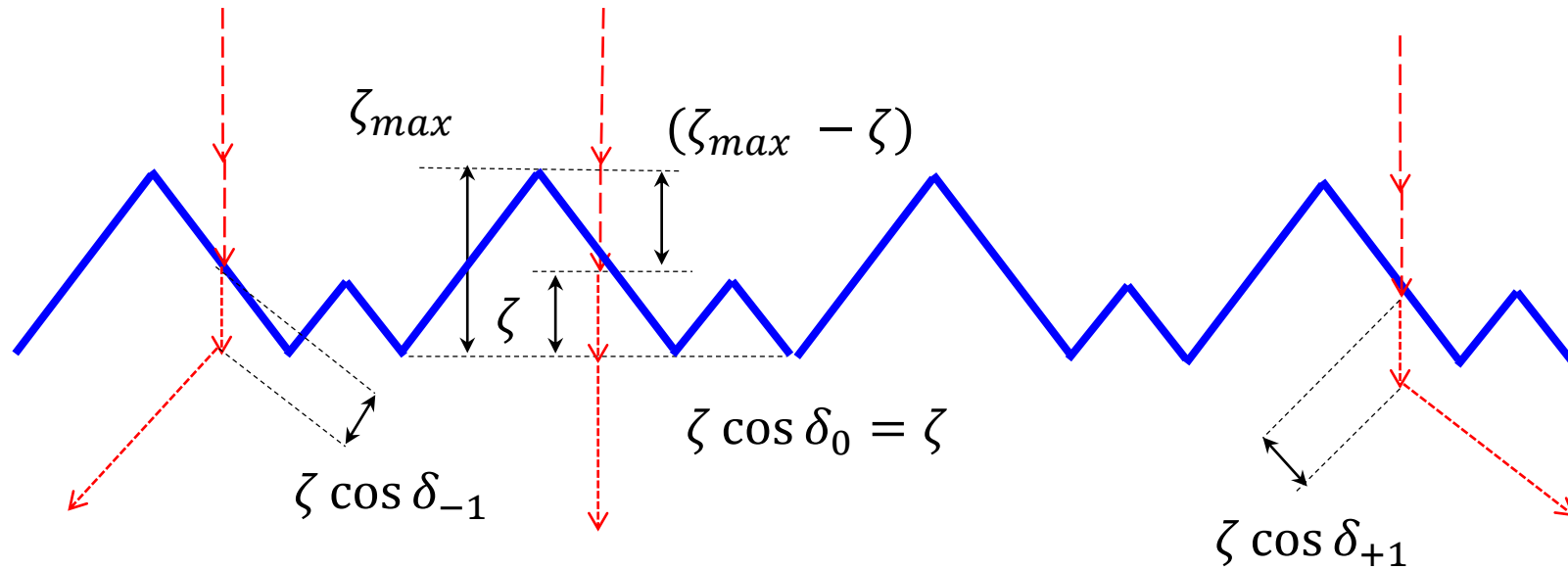
Harvey, JOSAA (2006)  
(defined for reflection)

# EPFL Removal of paraxial error



Corrected Fourier model reproduces Snell's law

Issue:  $\delta_q$  varies with  $q =$  diffraction order  
fine for discrete definition, just slow, especially for 2D  
BUT: FFT no longer applicable

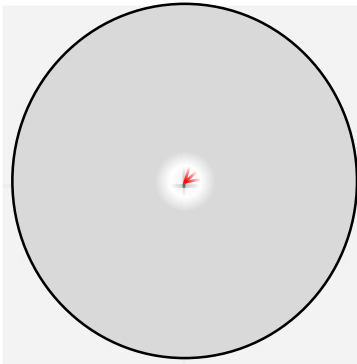


Consider perpendicular incidence  
 Define  $U_t$  for  $q = 0$ , calculate  $FFT_0$  (fast)  
 Define  $U_t$  for  $q = +1$ , calculate  $FFT_1$  (fast)  
 etc.

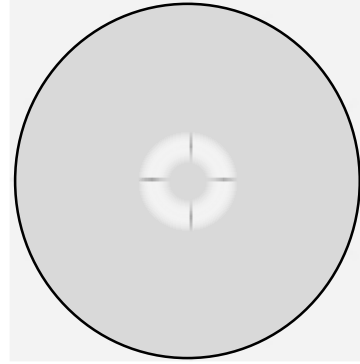
$FFT_1$  is also applicable for  $|q| = 1$  (great for 2D data!)

Example: calculate 10 patterns  
Perfect pyramid ( $n = 1.5 \Rightarrow$  Snell refraction into  $22.9^\circ$ )  
Perpendicular illumination  $\Rightarrow$  rotationally symmetric 2D diffraction patterns

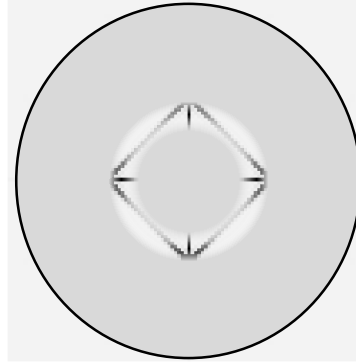
#1:  $0 \dots 6^\circ$



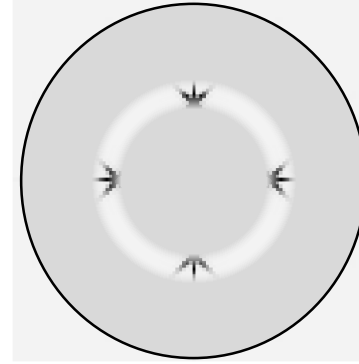
#2:  $6 \dots 11^\circ$



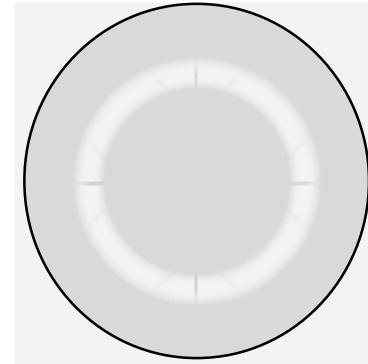
#3:  $12 \dots 17^\circ$



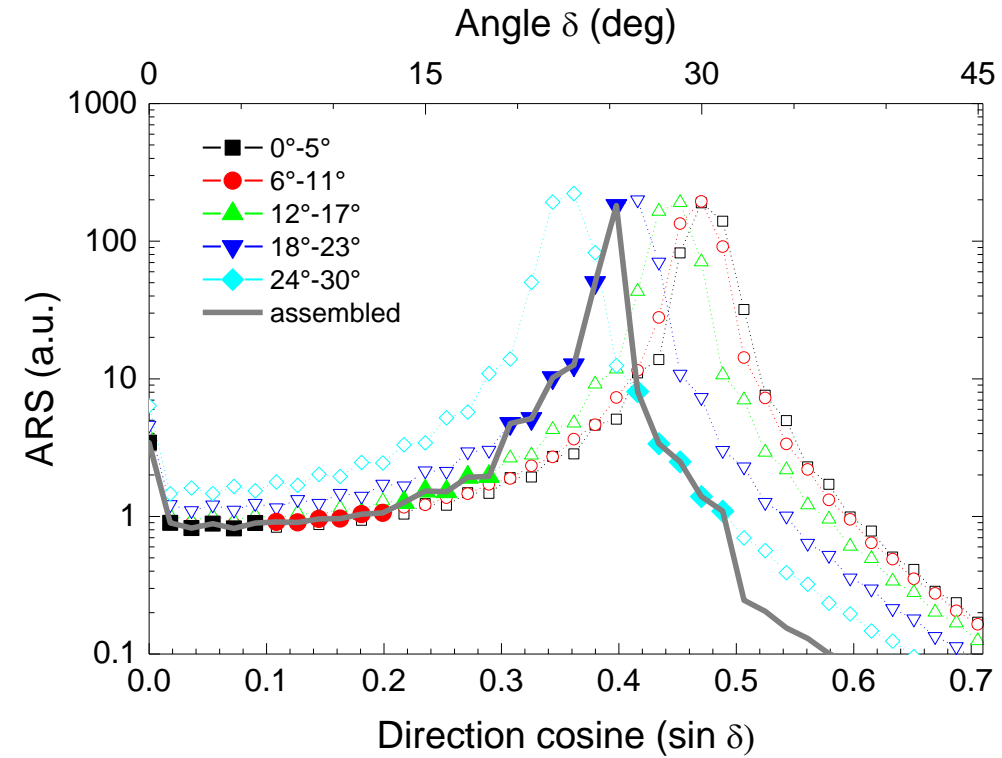
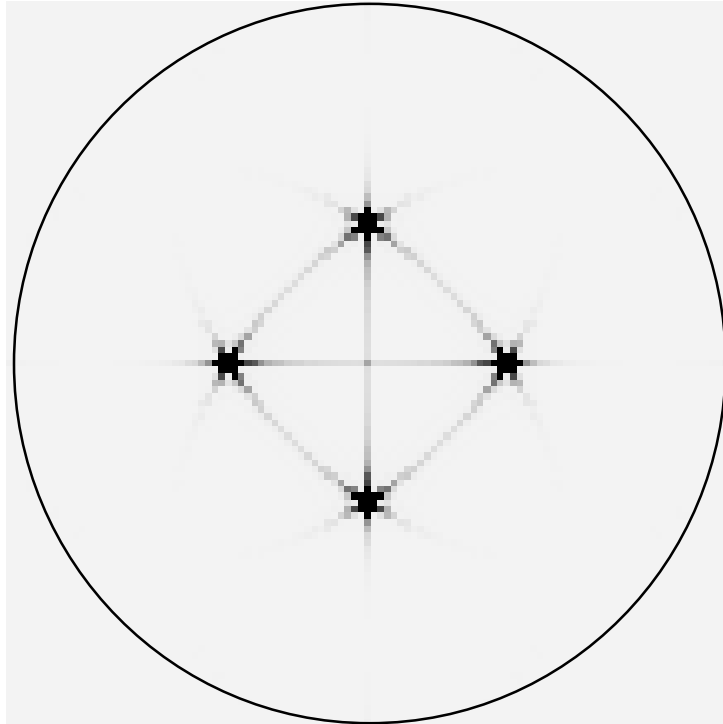
#4:  $18 \dots 23^\circ$



#5:  $24 \dots 30^\circ$



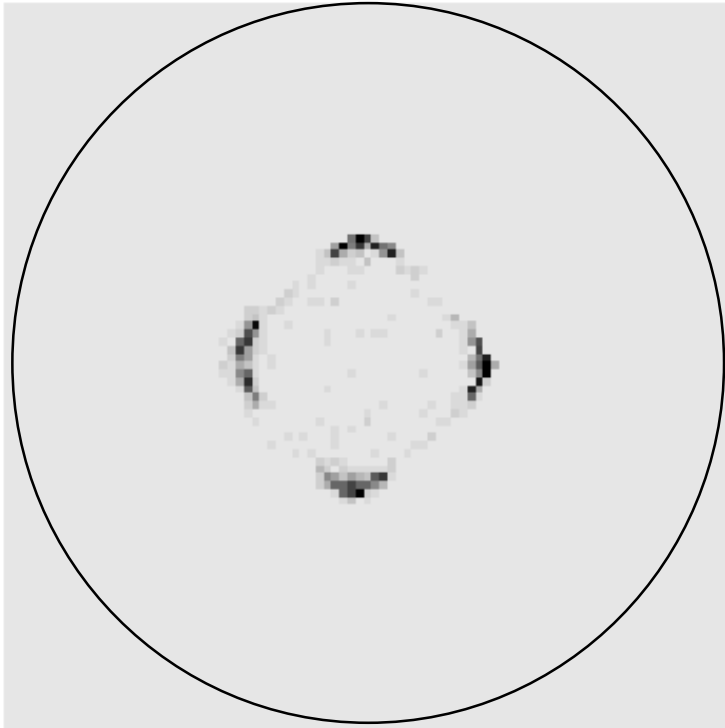
# Assembly of full characteristic



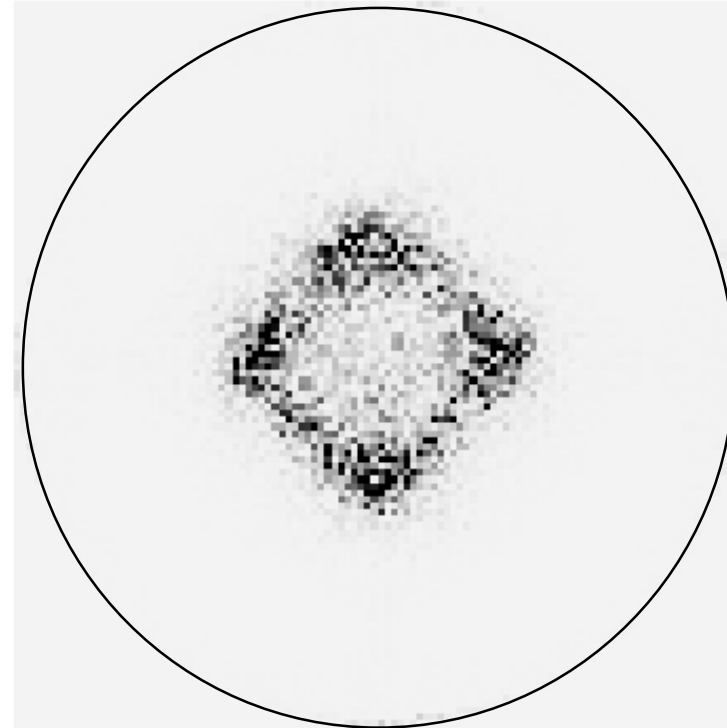
10 FFTs of 512x512 array; 12 sec with Mathematica on my laptop

# EPFL Ray tracing or Fourier model?

Compare predictions for AFM profile of large pyramids

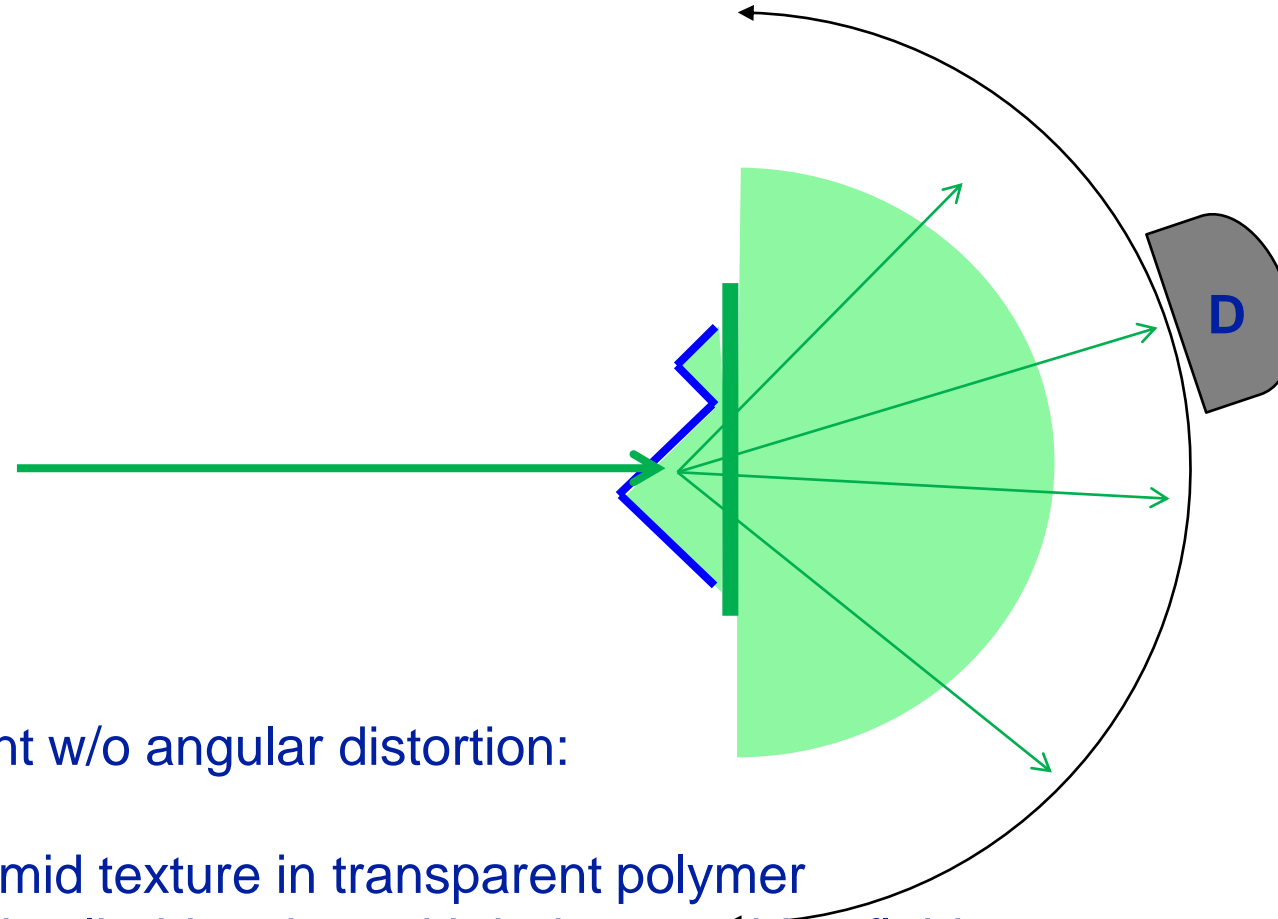


Ray tracing: four clear peaks



Fourier: broader peaks w. connection

# Comparison with measurement ( $n = 1.5$ )



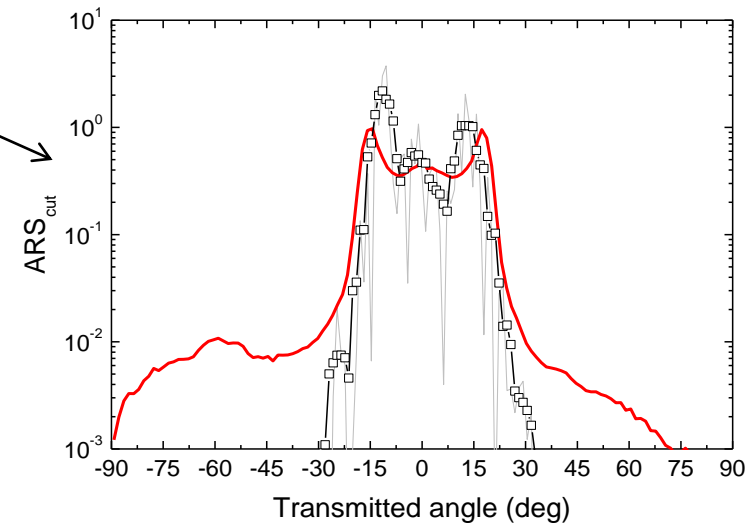
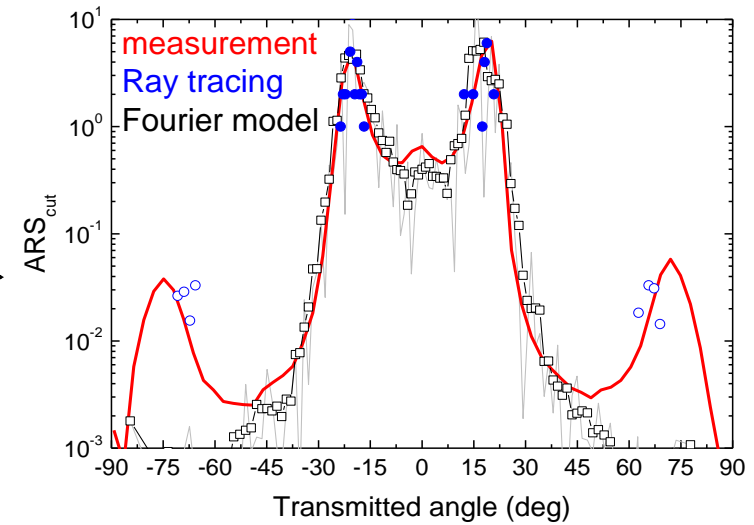
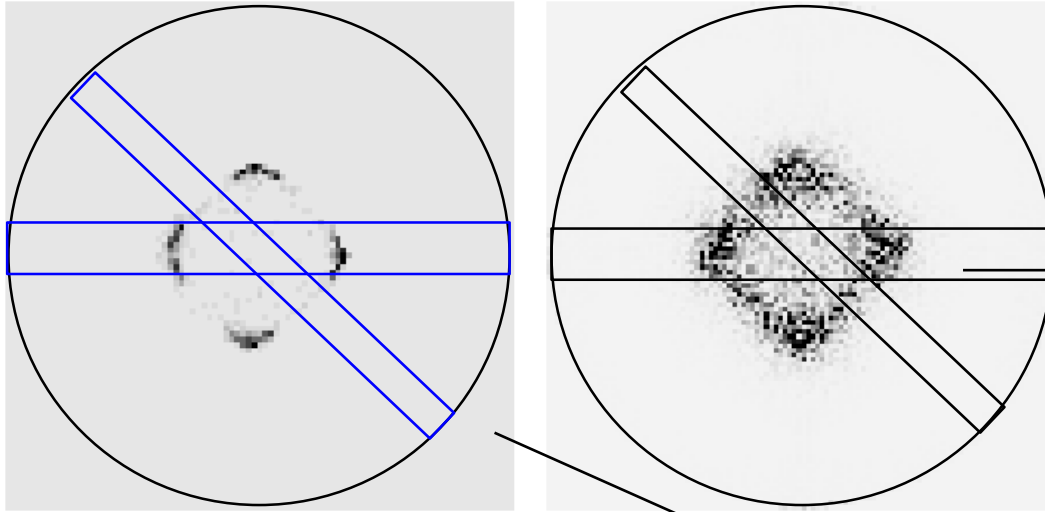
measurement w/o angular distortion:

replicate pyramid texture in transparent polymer  
attach to hemi-cylindrical prism with index matching fluid

Replica:  
Escarre, SolMat (2012)



# Comparison with measurement

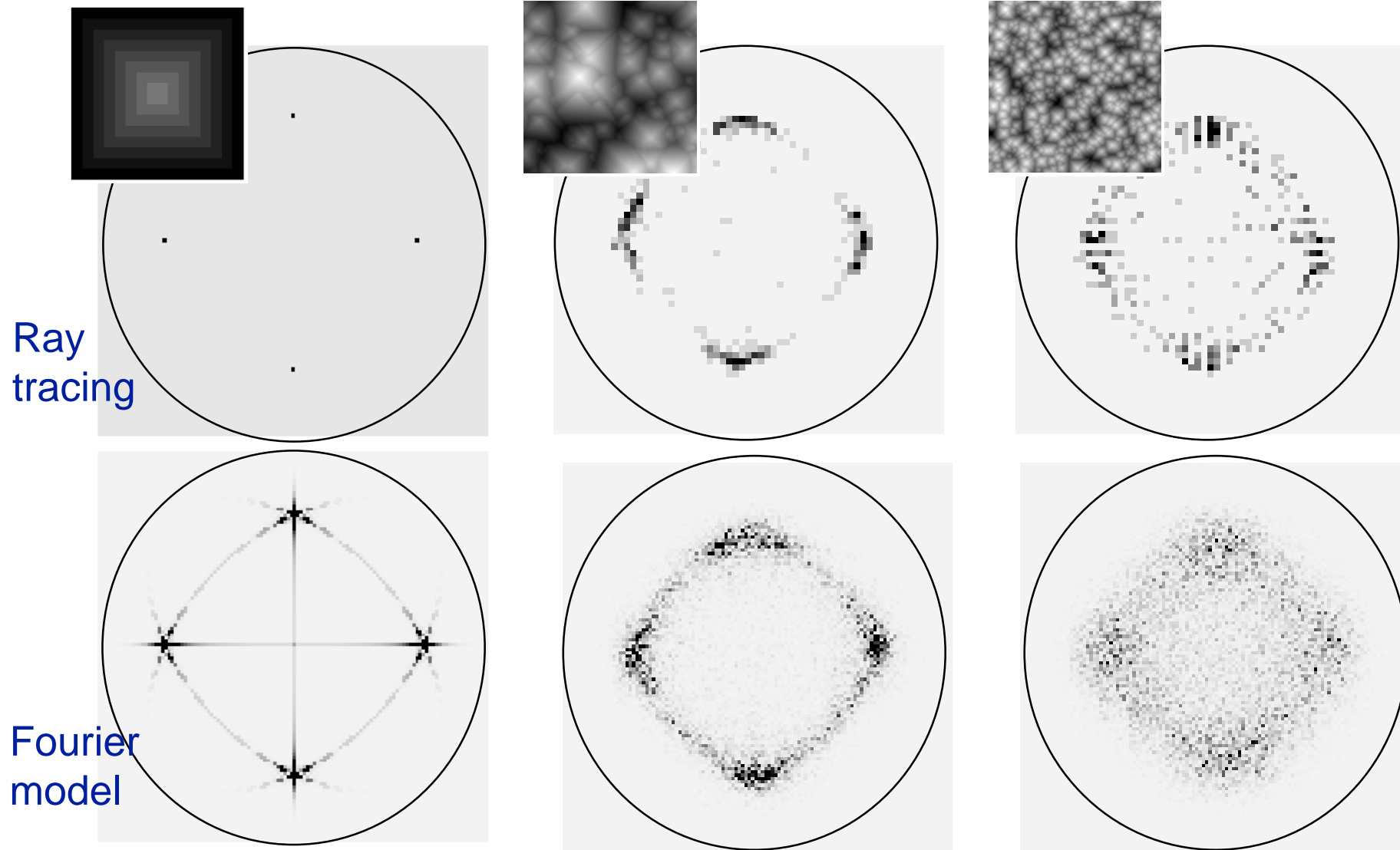


## Ray tracing:

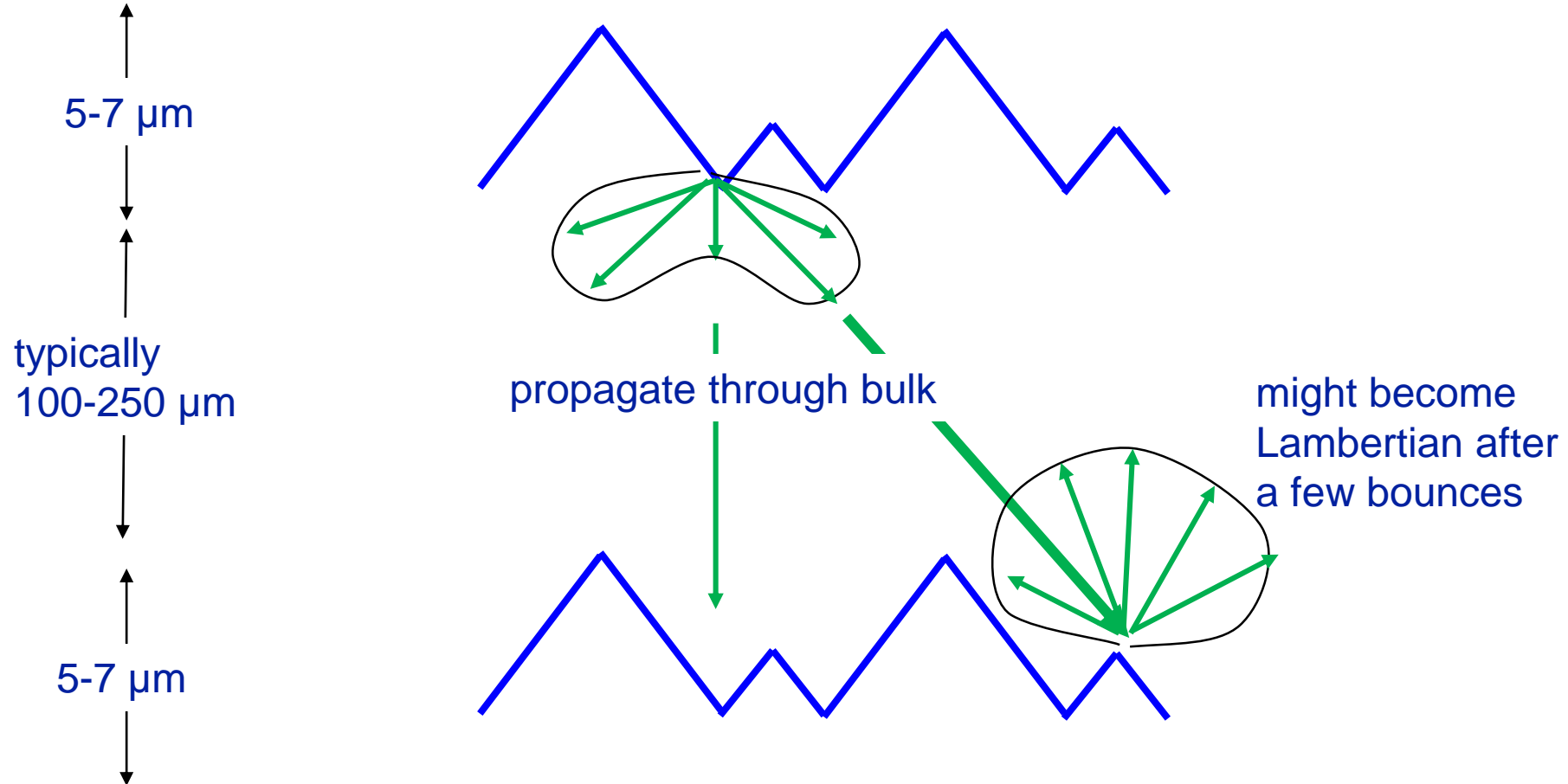
- peak positions reproduced
- 2<sup>nd</sup> rebound at high angles
- little or no signal along diagonal

## Fourier model

- Main peaks reproduced over 4 orders
- Diagonal over 3 orders
- But: no 2<sup>nd</sup> rebound

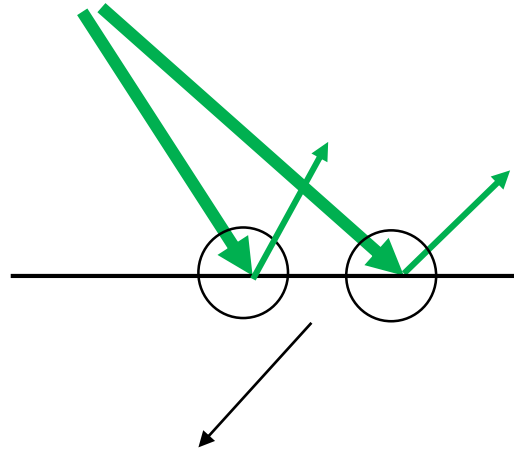
Refraction vs. diffraction into silicon ( $n = 3.5$ )

# Use in a combined modelling approach



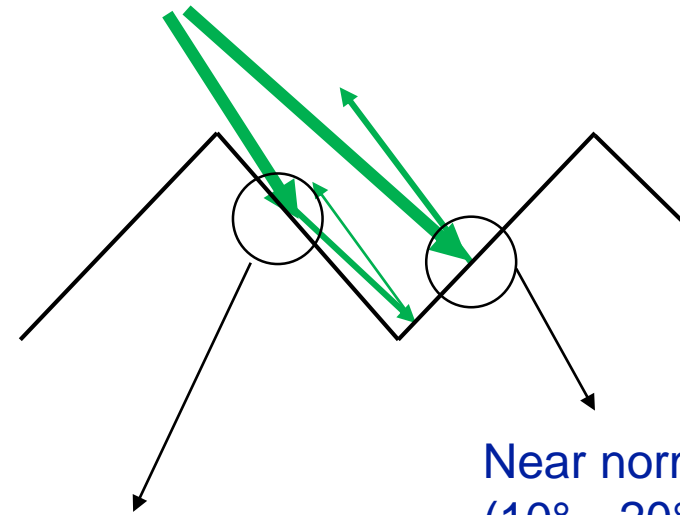
# EPFL Back reflector

Flat



Incidence btw.  $40^\circ$  and  $60^\circ$

Textured

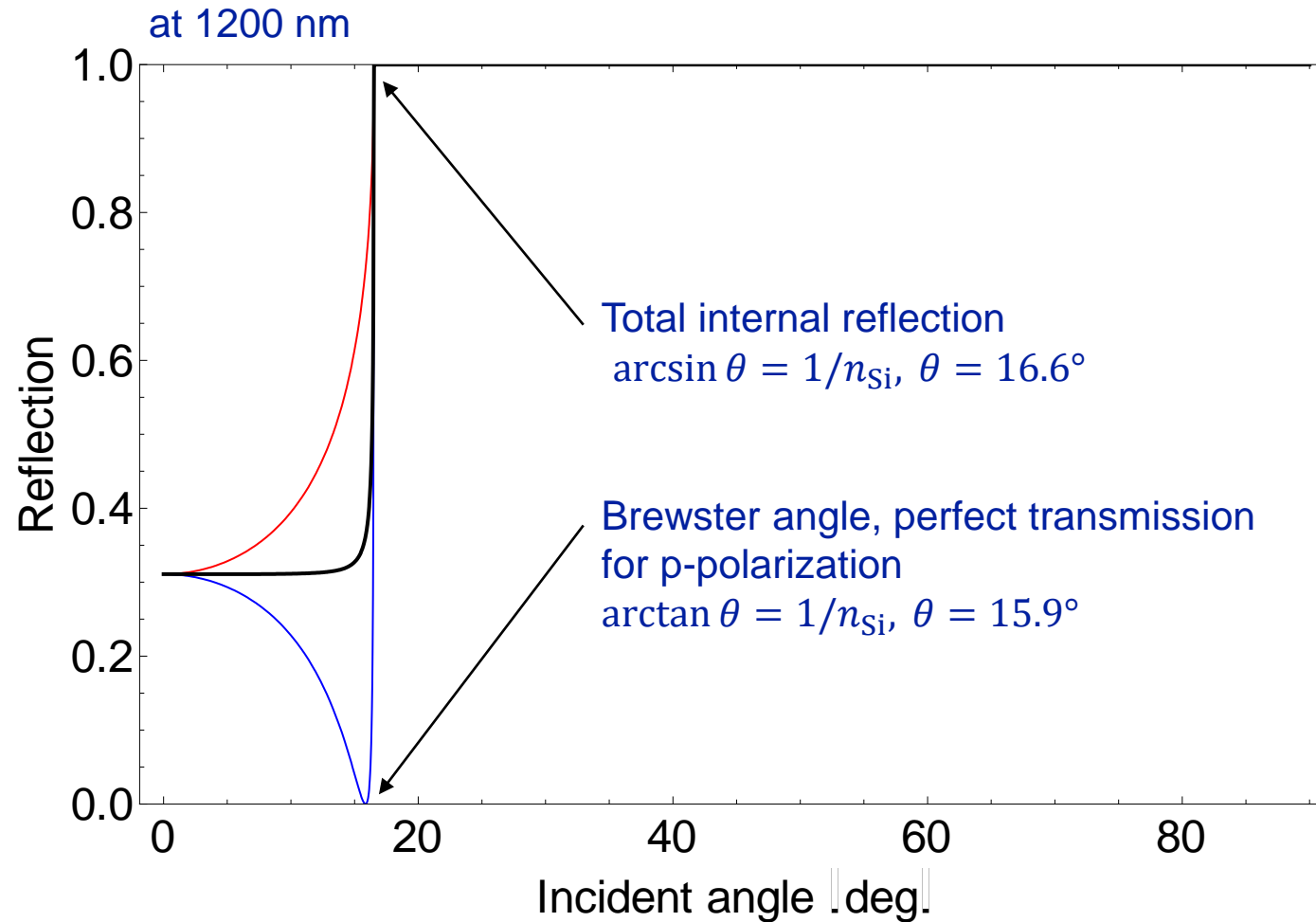


Grazing incidence  
( $70^\circ \dots 80^\circ$ )

Near normal incidence  
( $10^\circ \dots 20^\circ$ )

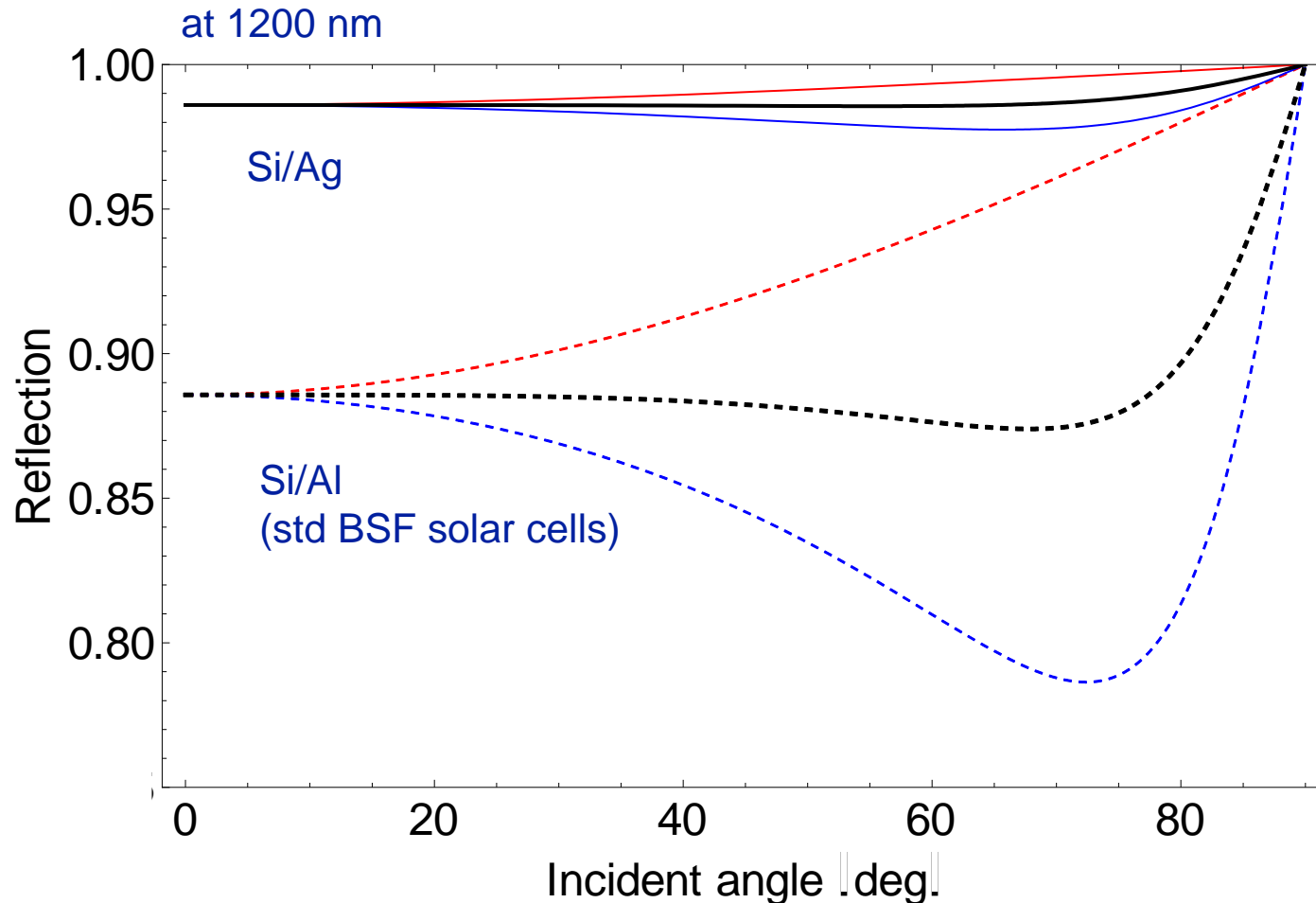
need to study angular properties  
important only at long wavelengths, e.g. at 1100 or 1200 nm

# Angular reflection out of wafer (Si/air)



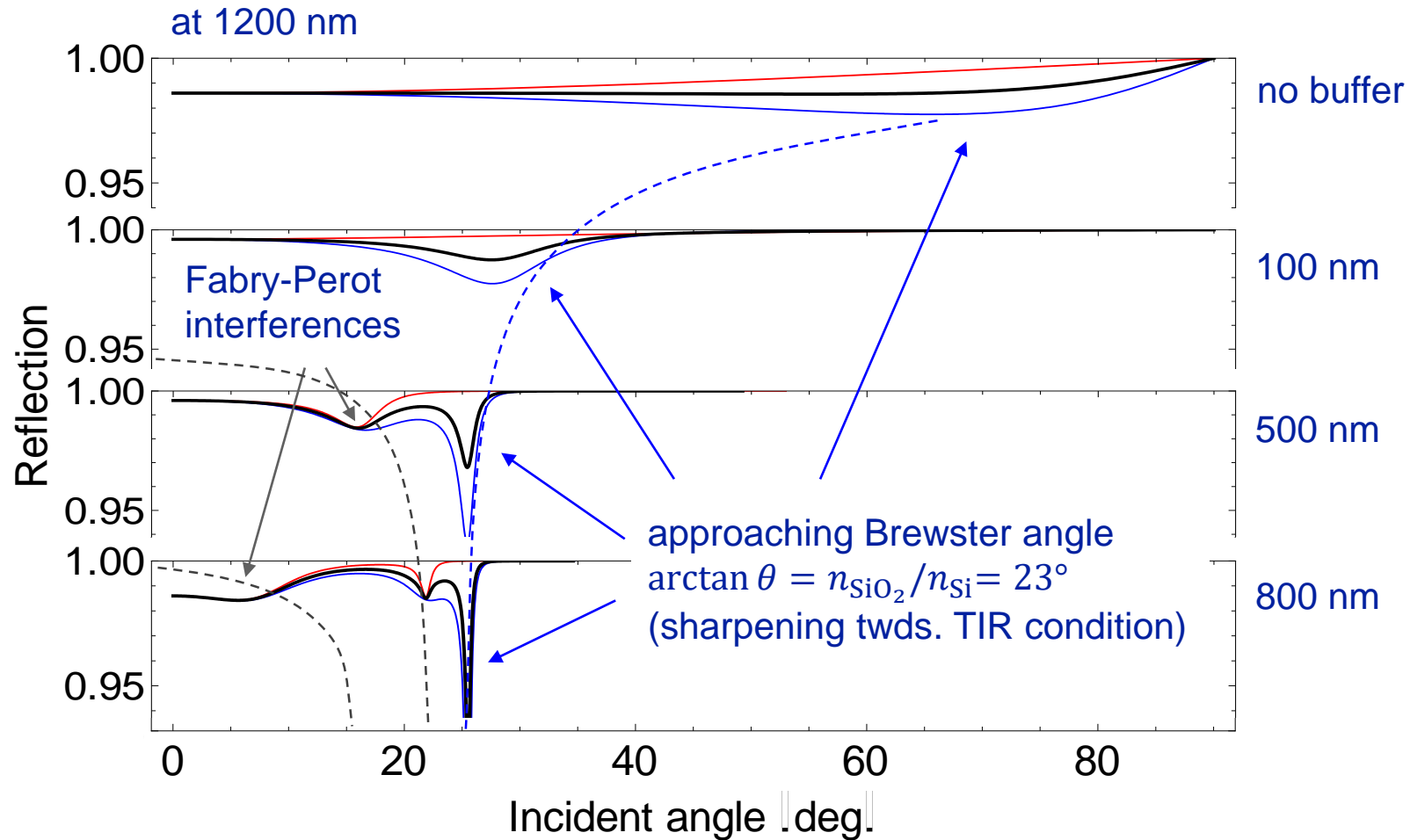
more information: Holman, JAP (2013)

# Back surface with metal contact



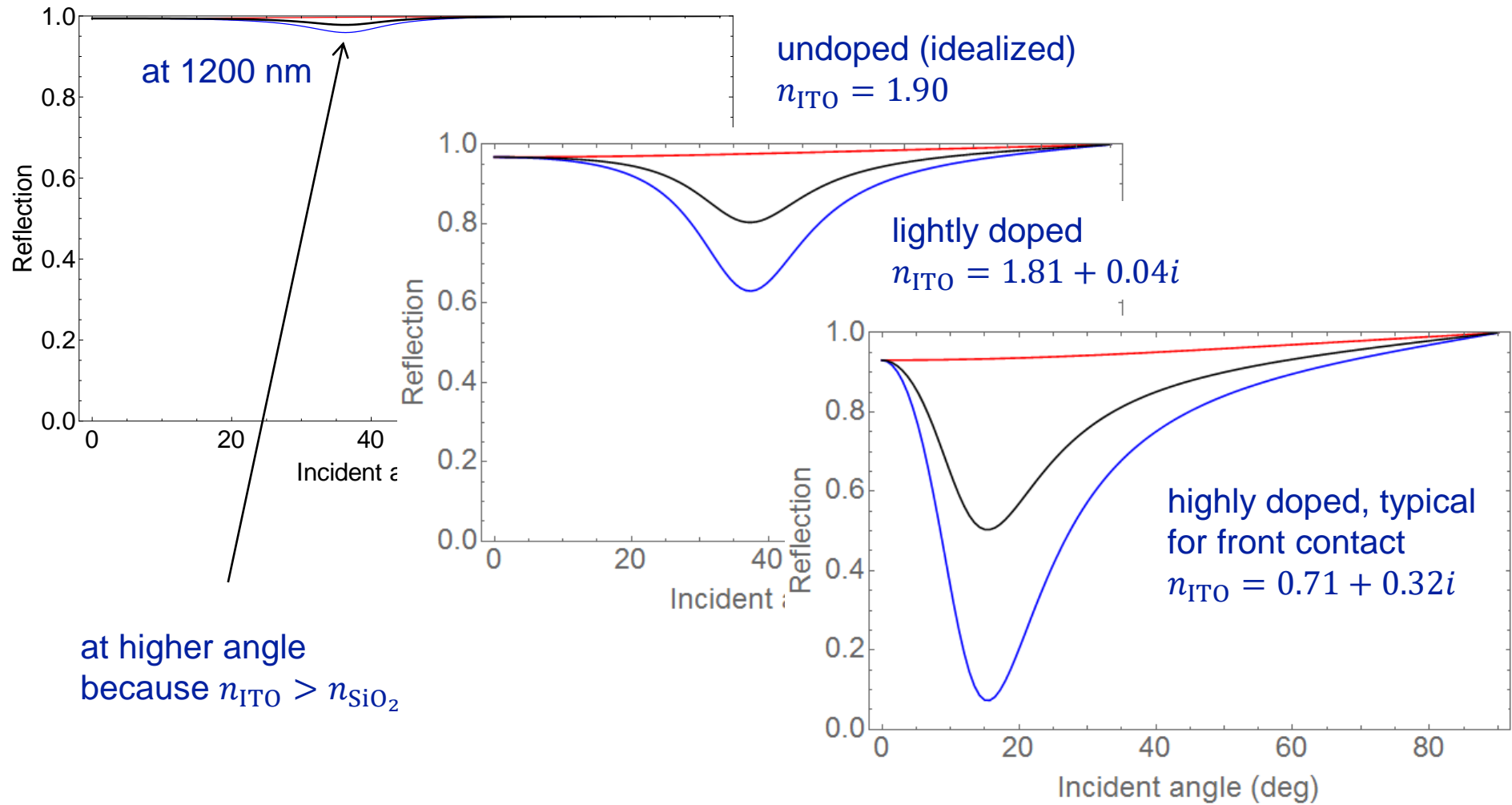
better for low angles (even with Al), much worse for high angles (no TIR any more )  
Technological constraint: massive recombination at semiconductor/metal interfaces

# Ag back surface with SiO<sub>2</sub> buffer layer



Used in high-efficiency PERC and PERL cells, but needs contact openings in SiO<sub>2</sub>

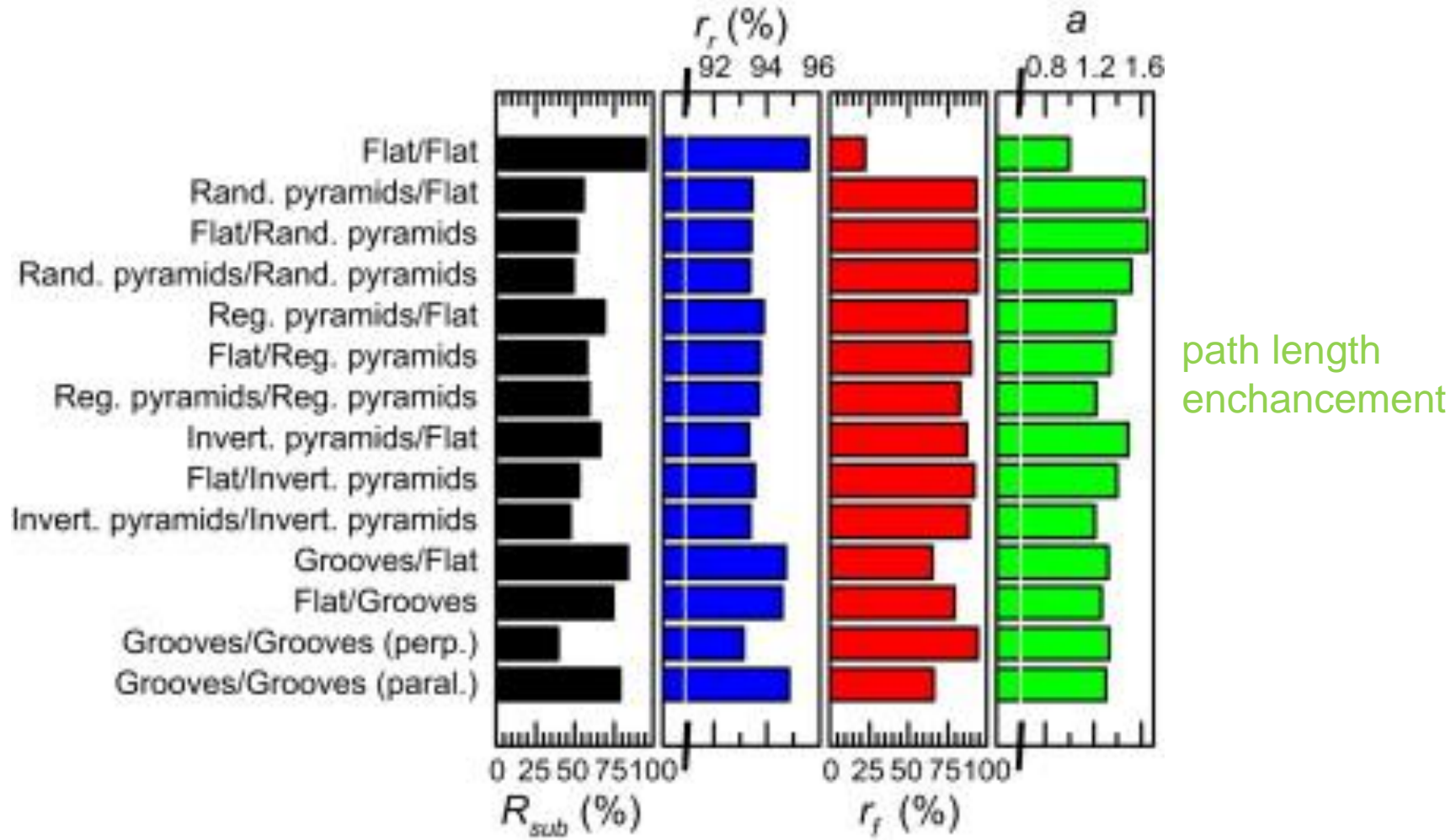
# Ag-back contact with ITO buffer (HIT cell)



Use lightly doped material (needs only out-of-plane conductivity for 100 nm)



# Combine ray tracing of front and back



path length enhancement

Holman, SolMat (2014)

- Excellent light trapping in silicon with pyramids
  - AR-effect by double rebound
  - path length enhancement
- Boost by single layer AR coating  
=> needed anyway
  - passivation (100 nm  $\text{SiO}_2$  or 70 nm  $\text{Si}_3\text{N}_4$ )
  - contact (70 nm ITO)
- Thinner wafers (near future) may require smaller texture